

**A METHOD TO INCREASE CURRENT DENSITY IN A
MONO ELEMENT INTERNAL TIN PROCESSED
SUPERCONDUCTOR UTILIZING ZR OXIDE TO REFINE
GRAIN SIZE**

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Abstract

The effect of Oxygen on $(\text{Nb1Zr})_3\text{Sn}$ multifilament conductors manufactured by the Mono Element Internal Tin (MEIT) process was explored to improve the current density by refining the grain size. This followed work first done by General Electric on the Nb_3Sn tape process. Techniques to fabricate the more difficult Nb1Zr composites are described and allowed fabrication of long lengths of .254 mm diameter wire from an 88.9 mm diameter billet. Oxygen was incorporated through the use of SnO_2 mixed with tin powder and incorporated into the core. These were compared to samples with Ti+Sn and Cu+Sn cores. Heat treatments covered the range of 700°C to 1000°C. Current density vs. H, grain size, and reaction percentages are provided for the materials tested. The Oxygen gave superior results in the temperature range of 815-1000°C. It also stabilized the filament geometry of the array in comparison to the other additions at the higher temperatures. At 815°C a peak in layer J_c yielded values of 2537 A/mm² at 12 T and 1353 A/mm² at 15T, 8-22% and 30-73% greater respectively than 700°C values. Results with Oxygen at high temperature show the possibility of high speed continuous reaction of the composite versus the current batch or react in place methods. In general the Ti additions gave superior results at the lower reaction temperature. Future work is suggested to determine if the 815°C reaction temperature can lead to higher current density in high tin $(\text{Nb1Zr}+\text{O}_x)_3\text{Sn}$ conductors. A second technique incorporated oxygen directly into the Nb1Zr rods through heat treatment with Nb_2O_5 at 1100°C for 100 hours in vacuum prior to extrusion. The majority of the filaments reduced properly in the composite but some local variations in hardness led to breakage at smaller diameters.

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a. Identification and Significance of Problem

The High Energy Physics community has been encouraging and sponsoring the development of Superconductors for Accelerator applications for over forty years. The Superconducting Tevatron at Fermilab and the Large Hadron Collider (LHC) under construction at CERN are evidence that these efforts have born fruit. It would be fair to say that superconductors have been an enabling technology for many of the community's discoveries over the last several decades.

Accelerators of today make use of the workhorse of superconductivity, Niobium Titanium (NbTi). This material provides operational fields of up to 8.4 Tesla as in the LHC. To substantially increase the energy of future accelerators requires significantly higher fields as well as lower cost for a given performance¹. The development of Nb₃Sn dipoles has progressed significantly in the last few years. Lawrence Berkeley National Lab² (LBNL), Fermilab³ (FNAL), Brookhaven National Lab⁴ (BNL) and Texas A & M University⁵ (TAMU) have all reported encouraging results. The LBNL group reported a new world's record dipole field strength of 16 Tesla from the experimental magnet HD-1². These programs are based on Nb₃Sn, a material of reasonable maturity but still with significant potential. Magnet technology, developed to utilize a brittle material such as Nb₃Sn, will also be applicable to the High Temperature Superconductors (HTS).

Superconductors for the next generation magnets as presently envisioned to support the VLHC concepts, have as goals a current density J_c of 3000 A/mm² at 12 Tesla in the non-Cu, an effective filament size of 40 microns, a 10,000 meter piece length and costs less than \$1.5 - \$1/kiloampere meter (\$/kAm)¹. Fields of 15 Tesla or higher are envisaged for the magnets.

b. Background

Niobium Tin in commercial production today utilizes two processes: -

1. The Bronze process first discussed by Pickett and Kaufman⁶ and by Tachikawa⁷.
2. The Internal Tin process (ITP) first discussed by Hashimoto⁸.

The Bronze process has found extensive use in high field NMR magnets and various research magnets. The internal tin process has evolved significantly from its original concept⁹ to meet the needs of the Magnetic Fusion community. The bronze process because of the inherent limitation of the amount of tin available to form niobium tin (9-10 at.%) compared to 23-24 at. % in the internal tin process is not a viable candidate for 15T accelerator magnet applications. It is also inherently more expensive because of processing and material factors. Internal tin on the other hand does not have these constraints and has been demonstrated in the earlier D20 13.5 T magnet built at LBNL¹⁰. Delivery of over eleven metric tonnes of conductor to a very demanding

specification for the KSTAR program by Luvata Waterbury (formally IGC ASI and OKAS) shows that this conductor has reached the industrial stage¹¹.

Niobium Tin by the internal tin process still has significant potential both in cost and performance but to achieve this potential, the process has to be optimized for High Energy Physics future needs.

The internal tin concept, as first practiced by Hashimoto, was not readily scaleable. Zeitlin et al adapted the concept utilizing the Luvata Waterbury (formally IGC-AS) 60 m draw bench to cold clad the individual sub-elements composed of a copper niobium composite with a core of pure tin⁹. The stabilizer tube is formed of copper and tantalum. The tantalum serves as the diffusion barrier preventing the poisoning of the copper by the tin. Niobium, sometimes used in combination with tantalum as well as by itself, has the disadvantage of forming a continuous layer of Nb₃Sn hence increasing the electrical losses. An illustration of that process is shown in Figure 1.

Initial deliveries were made to LBNL and BNL in long lengths from a 180 kg billet in 1983¹². Since that time much of the development has focused on Magnetic Fusion requirements epitomized by the ITER program. This had lower field, loss and current density specifications. Work by Gregory et al has made excellent progress in adapting conductors developed for Magnetic Fusion to HEP goals^{13, 14&15}. The J_c's were raised to 2550 amps/mm² at 12 T in the non-Cu¹⁵. The increase in current density was mainly due to increasing the volume fraction of niobium and tin.

The last stage of the Internal Tin Process (ITP) is the cold cladding of the array with copper and tantalum stabilizer. The larger the number of conductor elements the greater the surface area. This leads to increased difficulties in establishing the bond for reasons possibly related to the condition of the conductor before it is drawn and the pressure distribution as well as pressure intensity on the inner elements. Also the greater surface leads to a higher probability that inclusions will be introduced. All of these factors result in lower yield through greater breakage.

A new improved internal tin process named the “Mono Element Internal Tin” (MEIT), shown schematically in Figure 2, has been developed under the DOE SBIR program contract DEFG0299ERE82899. The process takes the single element multifilament and draws the element to an intermediate size where it is then clad with a diffusion barrier and copper. It is then drawn to a fine size and incorporated into a cable with pure copper elements¹⁶. The process promises to be scalable to large scale utilizing 450kg billets at costs below \$1.5/kiloampere meter (kAm). Wire in continuous lengths of over 30,000 meters has been drawn to 0.14 mm. Figure 3 shows an un-reacted cross section of a MEIT conductor. Figure 4 shows a conductor at 0.142mm diameter. The fins composed of NbTa have been incorporated to separate the filaments which bridge after the formation of Nb₃Sn. Additional fins can be introduced to further reduce the magnetization

Figure 1.

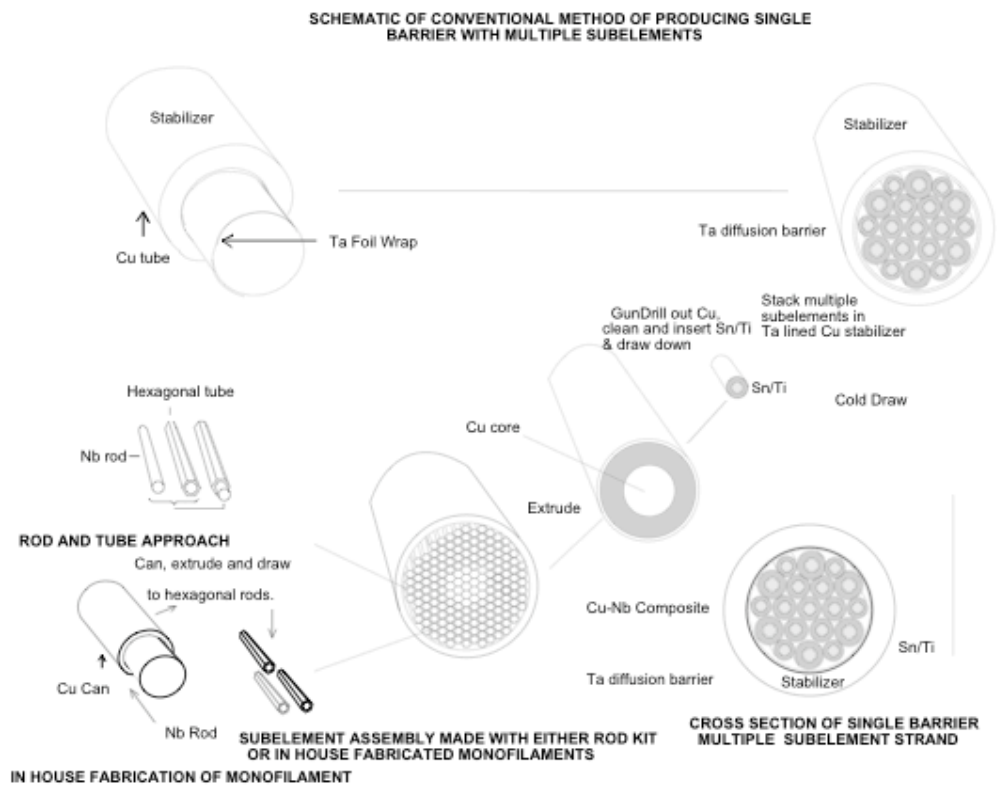
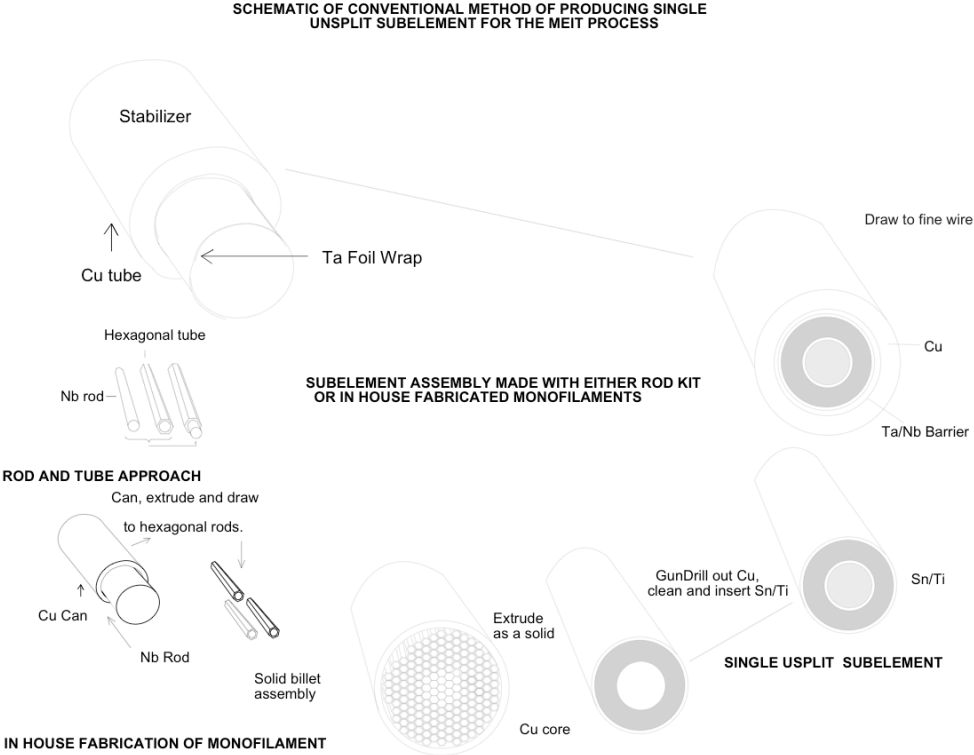


Figure 2.



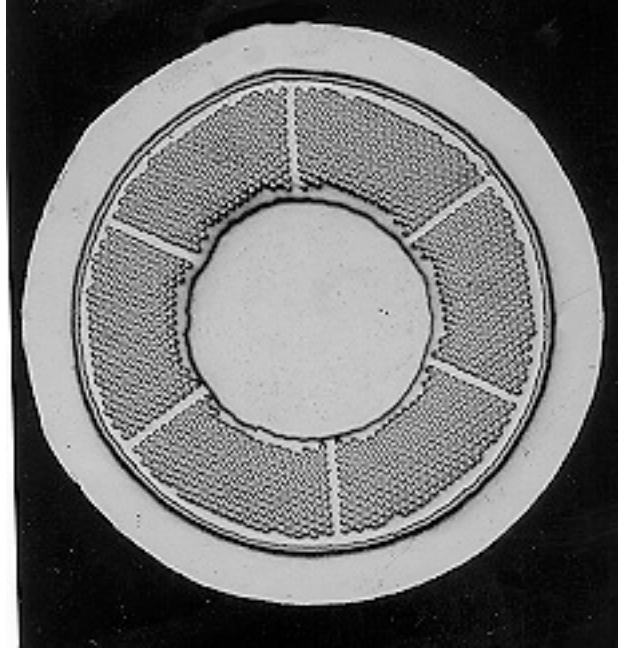


Figure 3., MEIT conductor (25x)

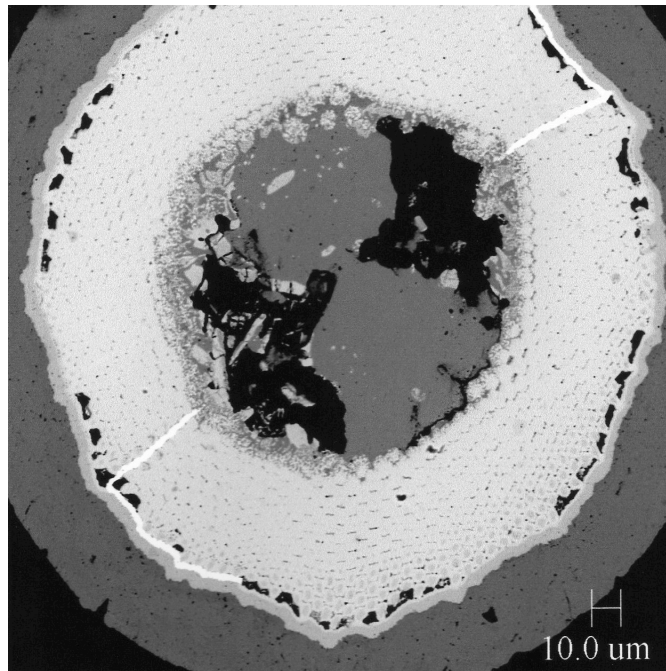


Figure 4., BAZ8 MEIT conductor at 0.142mm with Ta fins.

Conductor (BAZ7) produced with 2.5-micron filaments in contract # DEFG0299ERE82899 had a current density (in the Nb_3Sn layer normalized to the niobium) of 6365 A/mm^2 and 4579 A/mm^2 in the Nb_3Sn layer at 12 Tesla with a non-

optimized heat treatment. Tantalum fins were also introduced successfully for the first time to reduce the magnetization/effective filaments size of the conductor.

To achieve the 3000A/mm^2 in the non-Cu at 12T a large volume fraction of niobium and the appropriate ratio of tin are needed. In practice this requires that the copper be reduced to a minimum. At a local area ratio of .66/1 (Cu/Nb) all filaments within a segment are expected to bridge as the Nb_3Sn layer leads to an approximate 37% expansion of the filament volume. Increasing the local ratio of Nb to Cu beyond that may reduce and or slow reaction, as the tin must diffuse through Nb_3Sn . The highest Nb_3Sn layer current density reported in commercial conductors when normalized to the starting niobium is 5500A/mm^2 ¹⁶. To achieve 3000A/mm^2 in the non-Cu requires about 55% Nb by area and 25% Sn by area. This is difficult to achieve without improving the current density in the layer and this is one of the primary objectives of the research effort.

Layer current density

The inherent current density in the layer depends on the grain size, stoichiometry and impurities¹⁷. Titanium, as well as tantalum, is used commercially to significantly increase the high field performance by increasing the critical field and, in the case of titanium, speeding up the reaction kinetics¹⁸. Titanium is often introduced by alloying with the tin core. The highest current density is found in equiaxed grains, those initially formed¹⁹. To produce fine equiaxed grains a number of techniques have been explored. Phase II of the SBIR on the MEIT process yielded a current density of 3000 A/mm^2 at 12T and 1800 A/mm^2 at 15T with 2.5 micron Nb7.5Ta filaments and Ti in the Sn core. Fine filaments produce higher current densities as the reaction layer is composed of a larger volume fraction of equiaxed fine grains. Magnesium in the form of an oxide has also been used as a grain size inhibitor with limited success²⁰.

The early Nb_3Sn tape process as developed by GE and later practiced by Intermagnetics General, utilized a Nb 1%Zr tape as the substrate which was then anodized to introduce oxygen. The tape was then dipped in liquid tin/copper alloy and reacted. The process yielded 0.5 to 1 micron grains of Nb_3Sn at reaction temperatures above 930°C ²¹. Later work raised the reaction temperatures to 1050°C and reduced the grain size to 0.3 microns (300 nm). They also found that the current density was directly proportional to grain size²². This result confirms some early work done by Scanlan et al.²³

Work by Dietderich et al^{24, 25} using thin film deposition techniques showed that a film of Nb with Sc and Al_2O_3 and Sn resulted in a very high layer current density of $10,000\text{ A/mm}^2$ at 12T normalized to the starting Nb with a 20 to 25 nm grain size after 8 hrs at 700°C . In comparison a non-doped sample heat treated 60 minutes at 700°C had a J_c of 3500 A/mm^2 and a grain size in excess of 100nm. Current densities in titanium-doped materials had a lower bound value of 7000 A/mm^2 at 12T without any grain growth inhibitors. Work by P.J. Lee, et. al.²⁶, analyzed conductors made for the ITER program as well as others. The best conductors with Ti additions had grain sizes of approximately 110 nm with a layer current density of 3800 A/mm^2 at 12T. This is equivalent to 5200 A/mm^2 when normalized to the starting Nb. The potential for

significant current density improvement has been demonstrated. Improvements in current density without affecting the fabrication process significantly has the most leverage to improve the key measure of conductor performance, dollars/kilo amp meter (\$/kAm).

The key to further improve the performance cost of Nb₃Sn beyond what is envisioned with the MEIT process as well as any other internal tin process that can be fabricated in large billets is to improve the inherent current density in the layer. To do this we proposed to incorporate a demonstrated Nb₃Sn grain refiner Zirconium (Zr) and Oxygen into the Niobium.

At the High Field Materials-LTSW workshop on November 1-3 1999, Mark Benz and Judson Marte presented a work in progress to refine the grain size in a bronze processed Nb₃Sn. They utilized a Nb1%Zr filament with the required oxygen incorporated in the initial melting process. They successfully fabricated a 54mm diameter billet with seven filaments in a bronze matrix and processed it to a 1.73mm wire to yield a 0.17mm filament²⁷. A cross section of the conductor is shown in Figure 5. The outer filament shape is distorted and irregular possibly as a result of incorporating uncropped swaged ends in the extrusion. In addition the rods were machined from an “as cast” ingot by “Electro-Discharge Machining” (EDM) resulting in a coarse grain structure in the rod prior to extrusion.

Earlier work designed to speed reaction times in GE tape without loss of current density showed full reaction in 1/15 of the time with grain sizes about 1/5 of the size²². Figures 6 and 7 illustrated the dramatic effect of ZrO₂ on the kinetics and grain growth. Also demonstrated was the mechanism of grain refinement, a dissolution re-precipitation process that slowed the grain growth.

If ZrO₂ can be as effective in controlling grain size in a solid state reaction as demonstrated in the tape process and also demonstrated by Sc Al₂O₃^{24,25} in thin film work by Deitderich, then grain size could be reduced by a factor of two or more. All other things being equal this could well result in a doubling or more in the current density above the best materials in development today.

An alloy containing 1(at%) Zr was used throughout with the oxygen introduced in two different ways:

1. 2 (at.%) O₂ was introduced during the casting of the alloy.
2. The O₂ was introduced in the later stages of the fabrication by diffusion from a SnO powder incorporated into the tin core.

In Phase I the NbZr alloy containing oxygen prepared in the manner described in 1. above, did not extrude successfully in a Cu matrix at the same temperature (800°C) as that used for fabricating regular Nb-Cu composites. Although extrusion took place there appeared to be a very uneven reduction of the two components, Cu and Nb (1at.%) Zr containing oxygen. One reason for this appears to be a considerable difference between

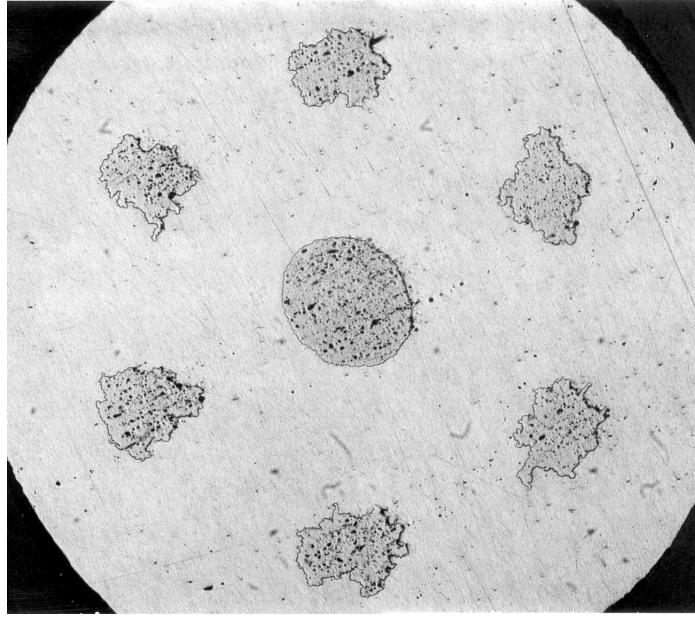


Figure 5, A cross section of 6 outer NbZrO₂ filaments and one inner Nb filaments at 2.5mm in a bronze matrix.

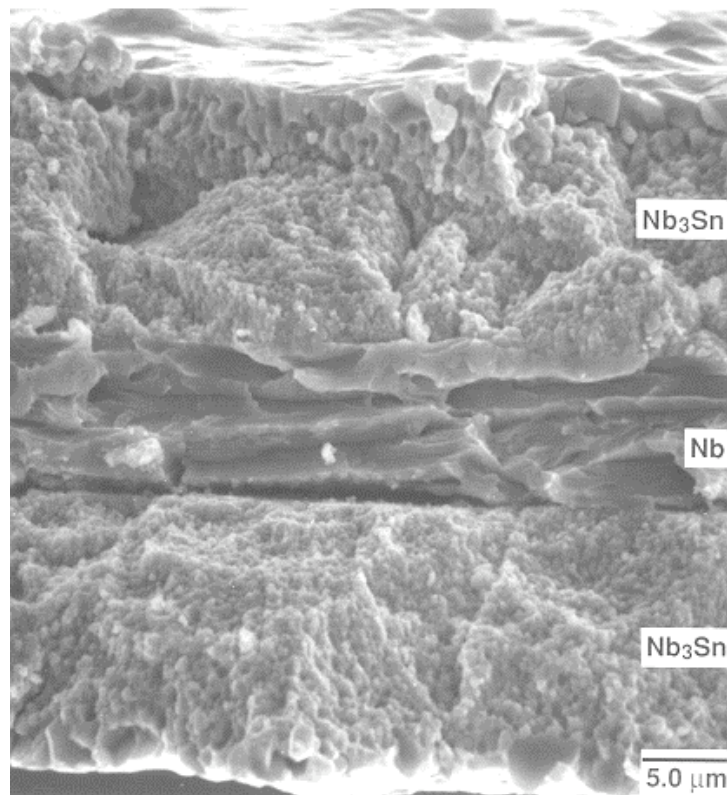


Figure 6, A NbZrO₂ tape 200s at 1050°C showing fine equi-axed Nb₃Sn grains.

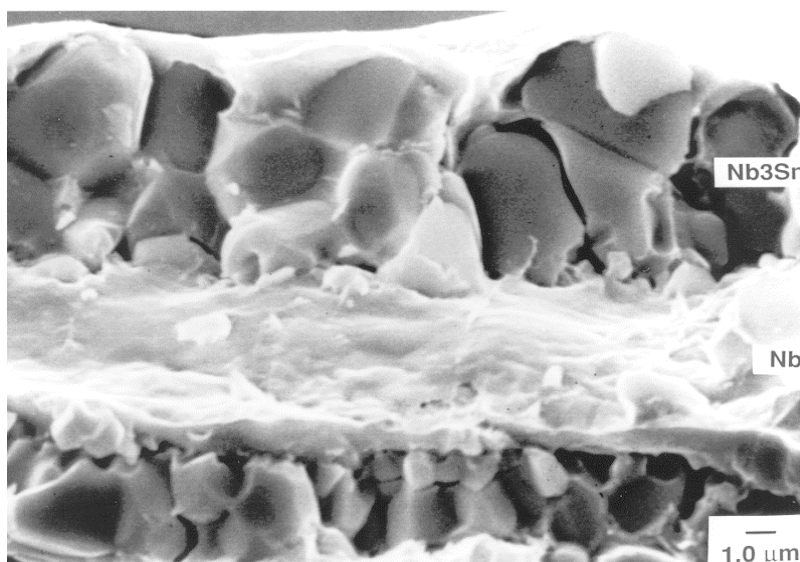


Figure 7, A Pure Niobium Tape with Large Nb₃Sn Columnar Grains after 3000s at 1050°C.

the strength of the Nb1at.%Zr alloy and that of Cu at this temperature, compared with that between pure Nb and Cu, (see Fig.8) Previous work carried out by General Electric on fully annealed material in a bronze matrix had shown that the same alloy could be extruded at 675°C and then drawn down at least to some degree. Presumably the bronze was significantly stronger than Cu in these extrusions. The data, shown in Fig. 8, for Nb1at.%Zr and Nb are taken from the literature²⁸. The Cu data is taken from the Metals Handbook and all are materials with relatively low O₂ contents. It is known however, that

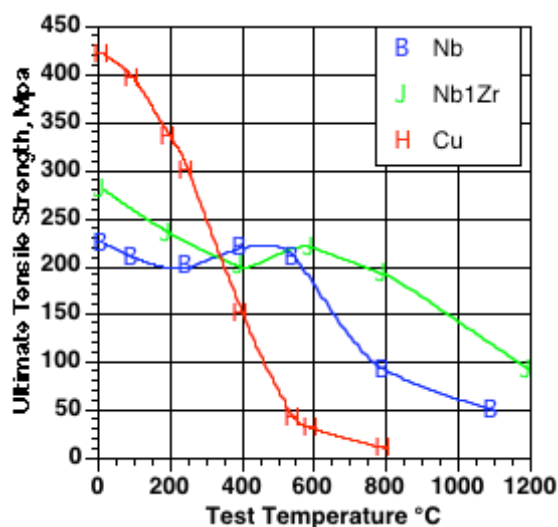


Figure 8. Comparative Tensile Properties of Cu, Nb, and low O₂ Nb1at%Zr.

niobium zirconium alloys can be markedly increased in strength in the presence of low partial pressures of oxygen during vacuum annealing for long periods in the temperature range 700-1000°C²⁹. In strained alloys the temperature for maximum hardening was found to be 800°C. The yield and ultimate tensile strengths of NbZr and NbWZr alloys at room temperature are reported by these authors²⁹ to have been doubled by internal oxidation of 1 mm thick sheet at 800°C and 1200°C for 100h. The creep resistance was also greatly increased as a result of this treatment. The alloy that we attempted to extrude in Phase I, already contained a significant amount of oxygen and was somewhat cold worked. It can be expected that, in this material, strengthening could have taken place more rapidly, possibly during billet heating prior to extrusion. Assuming that the oxygen was present in the same solution condition in the rods that were extruded satisfactorily by G.E. previously, the strengthening effect may have been less at 675°C, particularly as this material was in the annealed condition. In addition the bronze matrix is expected to have a significantly higher flow stress than the pure copper.

Lowering the temperature of extrusion and reducing the oxygen content was expected to facilitate homogeneous extrusion and this approach was explored in Phase I by extruding a billet containing commercial (relatively low O₂) Nb1Zr (at%) alloy rods at 450°C, a temperature shown in Fig. 8 to be one where the difference in tensile properties between Nb and Nb1Zr is small and Cu is much stronger than at the higher temperatures. Unfortunately this low temperature extrusion resulted in the introduction of a large amount of cold work and breakage problems were encountered when the wire was reduced below 1 or 2 mm in diameter. A review of the Avitzur criteria, indicates that the drawing parameters used may have led to filament sausage and then failure in spite of the ductility of the components. A short anneal at 800°C after the extrusion has solved this problem for processing this Nb1Zr based composites. Alternatively it may not be necessary to extrude at such a low temperature and this was investigated in Phase II. From this preliminary work it appears that it would be desirable if most of the fabrication could be performed on a Nb1Zr alloy that was low in oxygen. Ideally it would be best if the oxygen is introduced into the alloy when its dimensions are as close to the final one as possible. This is our second approach.

In an effort to fabricate the Nb1(at%)Zr into fine filaments in a Cu matrix and still produce additional pinning sites based on some form of ZrO₂, we explored the following approaches;

We first tested the fabricability of the Nb1Zr alloy as it is available commercially and determined if it shows a finer grain size of Nb₃Sn than that made from Nb.

It has been shown previously by LBNL that the grain size of an as cast Nb1%Zr a 34.9mm (9.5") billet from Reference Metals Corporation (RMC) was measurably smaller than that of a similarly processed Nb billet. Comparing Figs. 9 and 10 shows this.

The indications from the work carried out in Phase I of this contract are, that if we choose the extrusion conditions carefully, this material can be successfully extruded and although some problems were encountered while reducing the material to wire, it is expected that by modifying the fabricating conditions, these will be overcome. It remains to be shown how the grain size and properties of the Nb_3Sn formed by reaction with Sn in this material differ from those when pure Nb is the filamentary material.

Since our initial Phase I work we are now cognizant of the increased high temperature strength of the Nb1at%Zr alloy (Fig. 8) and its sensitivity to internal oxidation.^{28 & 29} Once we have determined how to process the regular alloy to fine wire we examined again the high oxygen alloy, its fabrication ability.

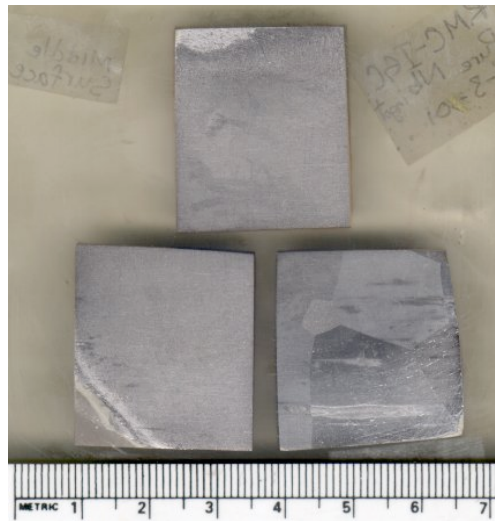


Figure 9. Polished and etched sections of the pure Nb “as cast” billet showing large grain size. Photograph courtesy of LBNL.

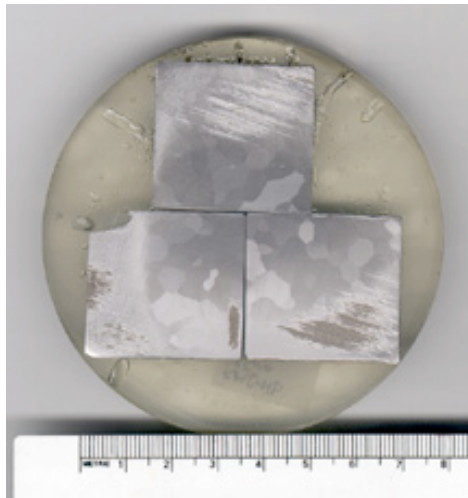


Figure 10. Polished and etched sections of Nb 1%Zr “as cast” billet showing a grain size smaller than that in Figure 9. Photograph courtesy of LBNL.

As expected this work shows a marked difference in the fabrication ability of the two alloys with different oxygen contents. Or second parallel approach introduces oxygen into the alloy at the final stage in the process, followed by an internal oxidization of the wire.

As has been mentioned above it is known that a marked increase in strength in this Nb1%Zr alloy can be achieved by annealing for long periods in a low partial pressure of oxygen during vacuum annealing on the temperature range 700°C to 1000°C.²⁹ This is due to internal oxidation and we will review this phenomenon briefly and show that it can be used to effect the objectives outlined, i.e. to introduce oxygen at a late stage in the manufacturing process.

Internal Oxidation.

The conditions for the formation of a stable dispersion of a compound BX in a metal A by diffusing element X into a solid solution of A and B have been discussed by many authors in the past starting with Rhines³⁰ and Meijering³¹ followed shortly afterwards by groups at the University of Cambridge, UK^{32&33} and MIT.³⁴

The ideal conditions are as follows:

1. X must diffuse more rapidly in solvent A than it does solute B otherwise a surface layer BX will be formed.
2. The free energy of formation of the compound BX must be much more negative than that of the compound AX.

When gases are soluble in metals they generally diffuse far more quickly than do metallic solute elements and therefore are ideally suited to the formation of a disperse phase by this method. In general noble metals alloyed with a small percentage of a metal having a high affinity for oxygen are very suitable for internal oxidation. Silver (top left corner of Fig. 11) is ideal as its oxide is unstable above 200°C³⁵, thus a stable oxide scale can be eliminated.

Internal oxidation also takes place in copper alloys despite the fact that a surface layer of oxide also forms. The dissociation pressure of Cu₂O at the heat treatment temperature governs the diffusion rate of the oxygen below this surface layer.

Ref. 29 reports that annealing at 800°C for 100hr. at pressures close to 10⁻⁶ torr, produces an appreciable strength increase in re-crystallized Nb1W1Zr alloys and suggests that a similar change takes place in the Nb1Zr alloy. Fig. 11 shows the free energy of formation of the oxides (where X=O). The larger the difference between the curves of the solvent, (A- Nb) and that of the oxide forming element (B-Zr), the smaller the precipitate and the more potent the hardening effect. The effect is obviously most significant in systems such as silver or copper with magnesium, aluminum or zirconium. There is however a significant separation between the NbO₂ and ZrO₂ curves [shown in red] confirming that strength increases can be expected by subjecting a niobium zirconium alloy to a low partial pressure of oxygen as has been reported.²⁹ The curves also show that it can be expected that the Nb alloy will reduce Cu₂O [also shown in red] and take up the oxygen from the Cu.

In green we have shown the curves for Sn and Ti. The TiO₂, while not as stable as ZrO₂ is similar to NbO₂ and may compete for oxygen at various stages of the heat treatment.

SnO_2 may not be a problem as it is less stable than most of the other materials.

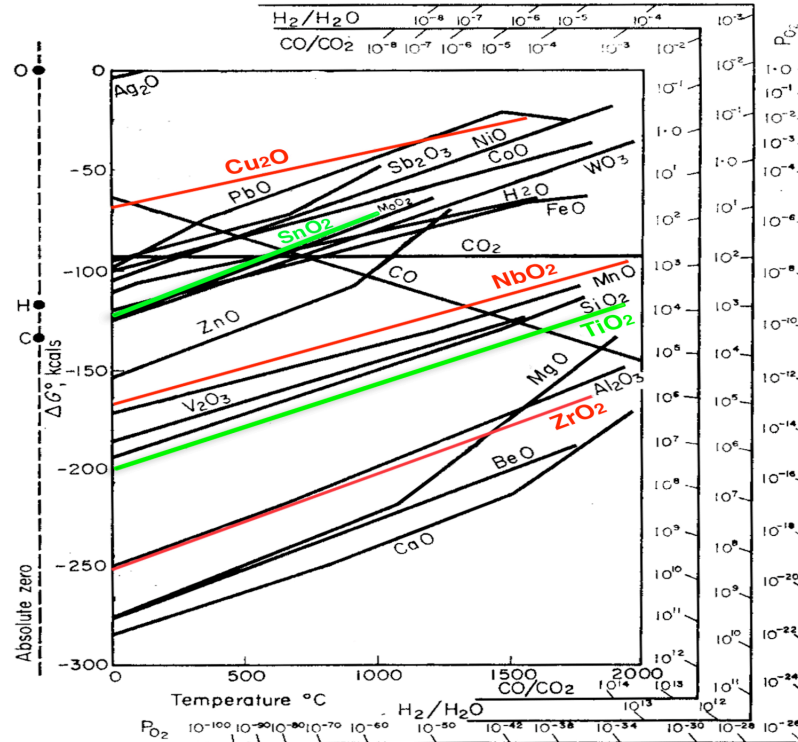


Fig. 11 ΔG° in free energy when one mole of gaseous oxygen at 1 atm. pressure combines with a pure element to form an oxide.

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The original objective was to load oxygen into the copper matrix by a number of means. This proved much more difficult than justified especially after development of introduction of oxygen through SnO_2 introduced through mixing the oxide with Sn powder for the tin core

Oxygen diffuses through metals upward from a 1000 times as fast as any metals diffusing through other metals³⁸ and so we anticipate having little trouble in getting the oxygen into and through the Nb to react with the Zr and form a fine dispersion of ZrO_2 ahead of the formation of Nb_3Sn .

It is known that exposing NbZr alloys to a low partial pressure of oxygen at 800°C produces the highest hardness²⁹ and this is presumably because it causes the best distribution of pinning sites for dislocations etc. to be created. Such distributions could also be ideal for pinning flux, reducing grain growth and thus for providing high J_c . A long time at 700°C or even 650°C the temperatures normally used to form Nb_3Sn , may also provide a satisfactory pinning array.

Table I gives the diffusion constants for O₂ in Cu, Nb and Ta taken from a paper by R. Kirchheim.³⁹ Values are calculated for D at both 700 and 500°C. The lower temperature is presumed to be more appropriate to diffuse the O₂ through the copper and into the Nb1Zr prior to reaction of the Nb₃Sn. It is realized however, that at 500°C oxygen diffusion may occur preferentially along the grain boundaries.³⁸

Table I Diffusion Parameters for Key Metals in Superconductor

Element	D ₀ m ² /sec	Q Kcal/mole	D m ² /sec at 500°C	D m ² /sec at 700°C
Cu	5.8 E-07	57.4	7.71 E-11	4.83 E-10
Nb	1.7 E-06	108	8.66 E-14	2.73 E-12
Ta	3.5 E-07	99.3		1.65 E-12

It has been shown in an infinite cylinder of radius L that equilibrium with the diffusing gas at the center is established based on the formula⁴⁰:

$$T(\text{time}) = .9^2 * L^2 / D \text{ (the diffusion constant)}$$

For a typical MEIT processed conductor, a likely wire size would be 0.25mm diameter (1.27 E-4 m radius) with a Nb1Zr filament size of 1 micron (1 E-6m) radius. With these assumptions at 500°C Table II gives the time to establish equilibrium with the surface atmosphere. As it can be seen this is quite short compared to homogenization and reaction times. Since the Zr will absorb the oxygen from the Nb and precipitate the oxide, the system acts as a pump to adsorb the oxygen as ZrO₂ until all is oxidized. Careful control of the oxygen through a partial pressure established in the vacuum system or provided by the O₂ in the tin core can be established such that the sufficient moles of oxygen will be available to precipitate the moles of Zr incorporated into the strand.

As can be seen conductors of other configurations at substantially larger sizes should also present no problem to internal oxidation.

Table II. Time to establish equilibrium of Oxygen within MEIT Conductor Element

Conductor Element	Temperature °C	Time sec/min
Cu, 1.27E-4 radius	500	4781/79
Nb filament 1E-6 radius	500	150/2.49

c. Technical Approach

There are two general approaches in which to make a cost effective superconductor for this application: -

1. Improve the current carrying capability of the superconductor.
2. Change the manufacturing process so that it is more efficient and less costly.

In contract # DEFG0299ER82899 we have concentrated on approach 2 by developing the MEIT process. In this proposal we are attempting to significantly increase the current carrying capacity of the strand. Most of the work in recent years with this objective in

mind has been to change the strand design so as to include the highest amount of Nb and Sn/Ti possible. This approach has yielded 3000 A/mm^2 at 12 T as demonstrated by the MEIT approach and Oxford but the d_{eff} of $40\mu\text{m}$ has not been achieved. This is difficult to achieve without improving the inherent current density in the filaments such that the amount of Nb could be reduced. With higher layer current density d_{eff} could be reduced by a combination of fins and or greater spacing of the Nb elements.

The objectives of this work were originally to investigate the above through the following work:

1. Replace the niobium filaments used in much of the internal-tin work with regular Nb1at.%Zr containing the standard amount of oxygen (i.e. <250ppm usually <100 ppm). Compare the grain size and the properties after reaction heat treatment with material without Zr. This will help us to determine the effect of Zr with and without Ti additions and without intentional addition of oxygen.

2. As a result of our Phase I work, it is suspected that there may be some limitations to the extent to which the high oxygen Nb1Zr can be made into the required superconducting strand. The second objective will therefore be to fabricate the low oxygen containing Nb1Zr close to finished size before introducing the oxygen into the alloy.

3. Repeat the work attempted in Phase I with Nb1Zr containing a significant amount of oxygen. (i.e. 2at% O_2) Again compare the grain size and the properties after reaction heat treatment. This will give us a better idea of the extent to which such material can be made into fine filament strand now that we are more aware of some of the limits to the conditions that can be employed.

8.1 Work on phase I material and oxidation experiments

The detailed objectives were:

1. Gather as much information as possible from the material produced in Phase I.
2. Determine the best extrusion conditions and thermo-mechanical treatment to process the low oxygen Nb1at.% Zr alloy.
3. Using a relatively simple billet assembly technique – rods and tubes in 89mm (3.5”) Ø billets- determine the effect of Zr and O_2 on the grain size and properties of the Nb_3Sn produced by reaction heat treatment. Compare them with those resulting from material without Zr and O_2 in the Nb.
4. To improve the overall I_c by lowering the amount of Cu inside the barrier, repeat some of the above by using Cu-clad rods in two conditions

Low oxygen in the Cu cladding

Higher oxygen in the Cu cladding

From the results of the work on 1 above, this objective has to be modified.

5. Again attempt to determine the fabricability of the high O₂ Nb1at.% Zr by processing a 50.8mm (2") Ø drilled billet and comparing the results with a similar one made using annealed Nb rods.
6. Finally prove the commercial viability of the approach by making and testing a 203mm (8") Ø or two 177mm (7") Ø billets using the techniques that have been shown to give the most promise in the preceding work.

The designs for the cans, noses and lids are shown in Figure 1. These have been made at Draher Machine Inc. in Waterbury CT and delivered to GE CRD. Oxide powders, Cu₂O, Ag₂O and SnO₂ were obtained by GE CRD.

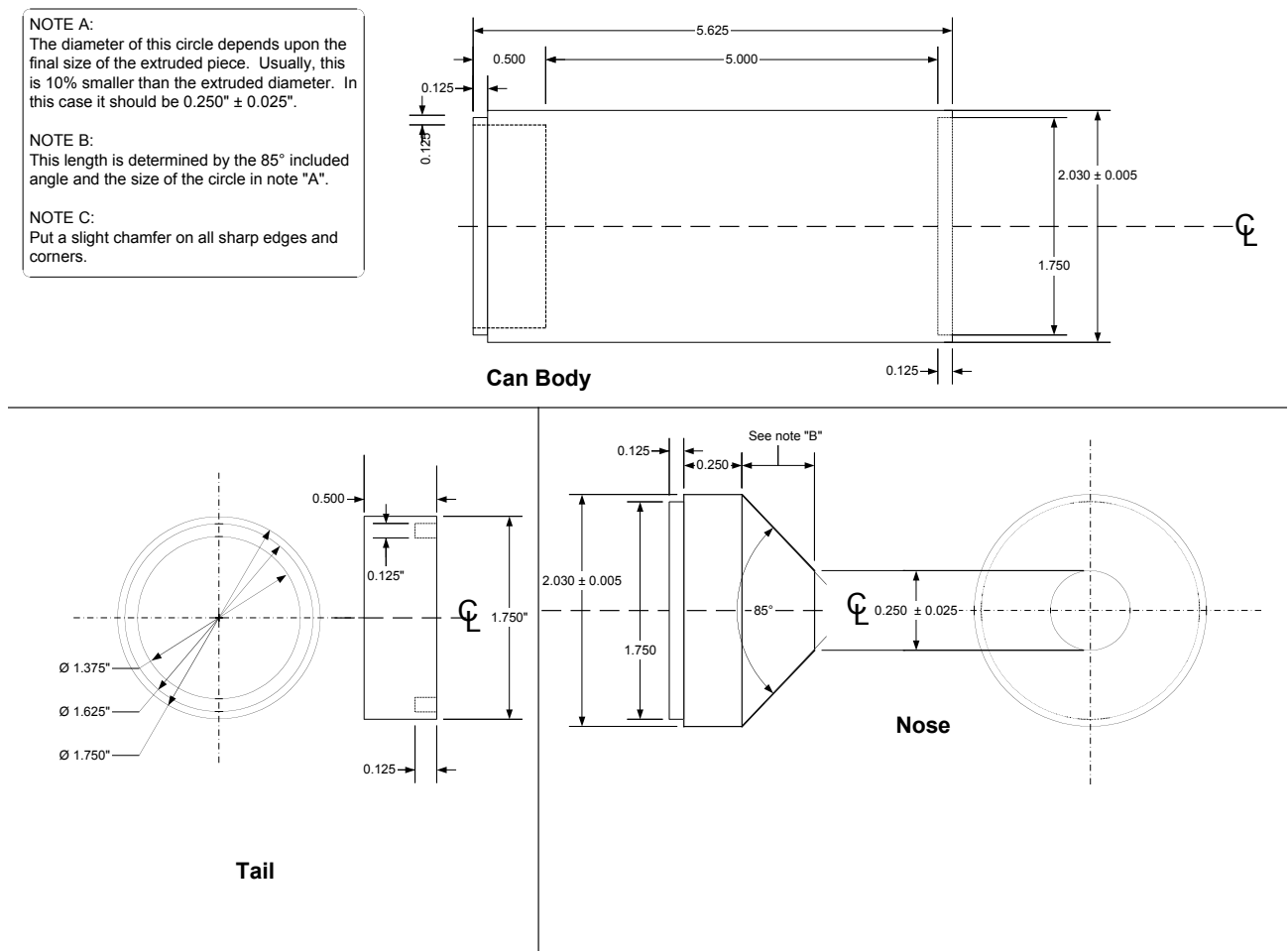


Figure 1.1. Design of the 2"Ø can, nose and lid

Materials for fixtures to hold the samples to be heat treated in quartz tubes were purchased and the fixtures built.

1. Examination and Testing of Phase I materials.

In Phase I, a billet was successfully extruded and 1000 mm of sound material at 21,3 mm diameter obtained. This was gun drilled with a 8.71 mm hole at Grover Gundrilling in Norway ME. The material was cut in half at Outokumpu Advanced Superconductors and pure Sn inserted into one rod (ZAB1B) and the usual Sn/Ti inserted into the other (ZAB1A). This material, although its filaments were significantly “sausaged”, was chosen for heat treatment and further analysis.

Table 1 summarizes the characteristics and the conditions under which the samples were treated. The samples were sealed in quartz ampoules and the heat treatment conditions were: ramp to 180°C at 10°C/h, hold for 24 hr, ramp to 340°C at 5°C/hr, hold for 24hr, ramp to 700°C at 25°C/h, hold for 47 hr and water quench.

Table 1

Sample ID	Diameter	Length	Mass					% wt of
	in	in	grams	Powder	quantity	grams in		sample
					grams	ampoule		
ZAB 1A #1	0.0365	2.063	0.29	none, control				
ZAB 1A #2	0.0365	2.063	0.3	Cu, Cu ₂ O, Al ₂ O ₃	0.2924			
ZAB 1A #3	0.0365	2.125	0.3	AgO	0.0159	0.0159	2 At% in sample	5.30%
ZAB 1A #4	0.0365	1.8125	0.26	AgO	0.0305	0.0305	4 At% in sample	11.73%

ZAB 1A #1

There was no oxygen in this ampoule and, if we assume that some of the colors are due to actual compositional variations and are not artifacts, the tin has diffused to the outer row of filaments although they are more reacted on the surfaces closer to the center. Figures 1.2 & 1.3, the maximum reacted layer (on the inner ring) is ~13μm.

There are several unusual effects compared with what we normally see while processing Nb containing Cu with Sn/Ti. There appears to be another layer outside the reacted layer on the filaments on the side facing the tin, Figure 1.3. The central tin area has no Sn/Ti inclusions although Sn/Ti was supposed to have been inserted. There also appears a pink phase presumably due to the presence of Cu. There is an outer layer of a different color and around the “black holes” in the center the pink is absent and the material looks to have polished as a harder material. The reacted layer (presumably Nb₃Sn) has a hardness of 503 HV₂₅, 51 Rc whereas the center of the filament is 164 HV₂₅, 85 Rc Figure 1.4. The sample was reported to have experienced a minor tin leak which may be the cause of central “black holes”.

ZAB 1A #2

Cu_2O appears to have had little effect on the amount of filament reaction, (Figures 5 & 6). No double layer on the filaments is visible. No tin leak was reported and no central porosity but significant porosity in the inner row of filaments and the outer part of the central core has less of the Cu phase and appears harder.

ZAB1A #3

This was heat treated with 0.0159 grams of Ag₀, 2 At.% in sample. Filaments still appear to have reacted to a similar extent as the first two samples. Still assuming the effects are not just artifact, there seems to be an asymmetry to the photograph. The inter-filamentary porosity on one side appears to be further into the filament array on one side. Also the core appears harder on one side than the other.

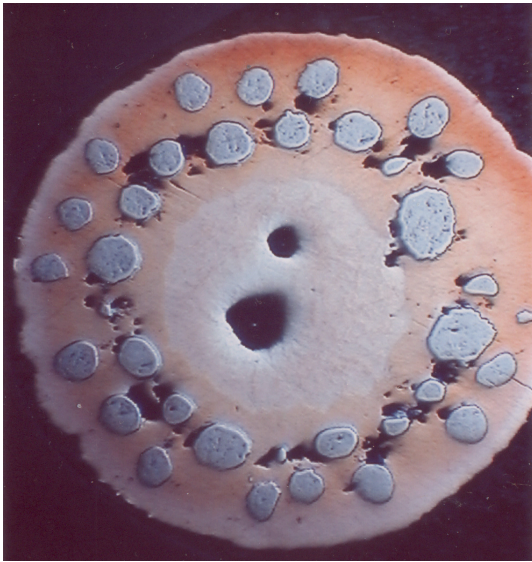


Figure 1.2. ZAB1A#1

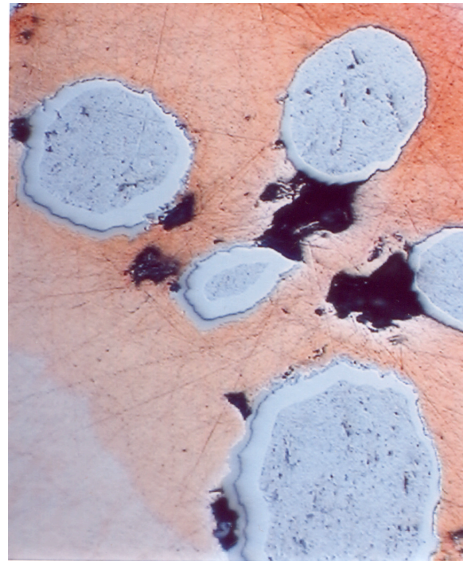


Figure 1.3. ZAB 1A#1 375X

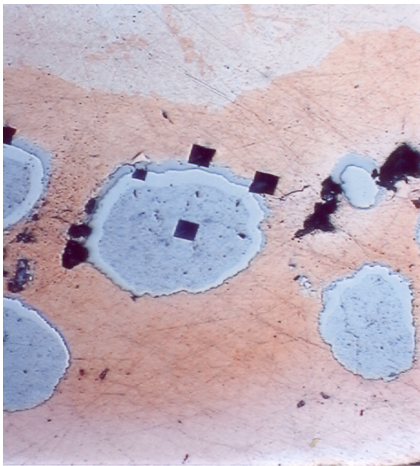


Fig.1.4 Hardness indentations ZAB1A X375

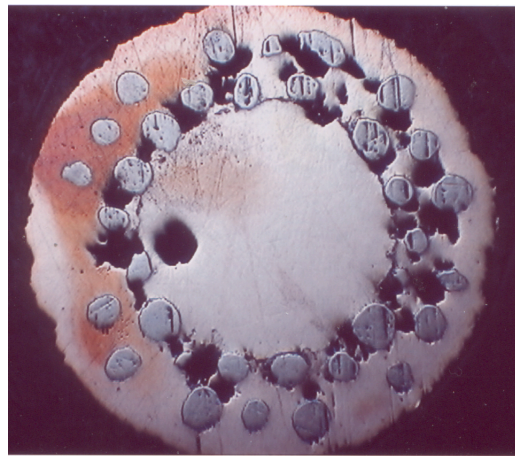


Fig. 1.5 ZAB 1A #2

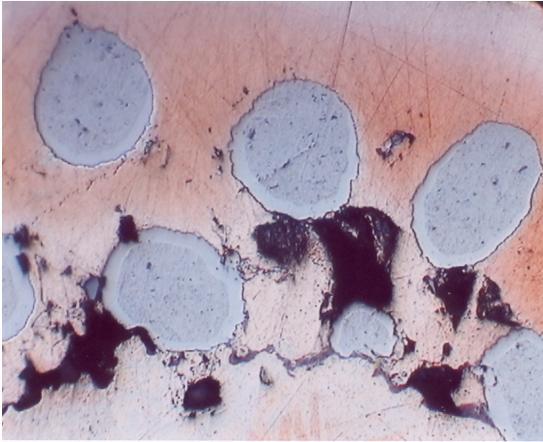


Fig.1.6 ZAB1A #2 375X

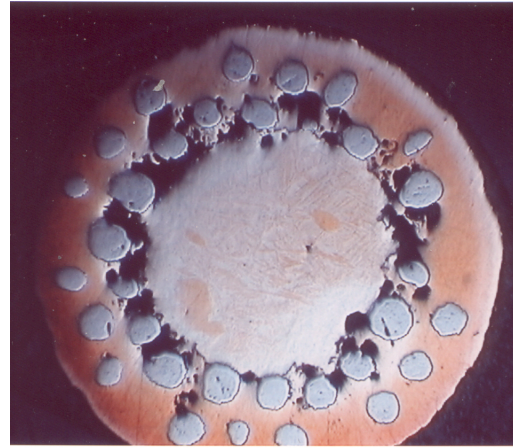


Fig. 1.7 ZAB 1A #3

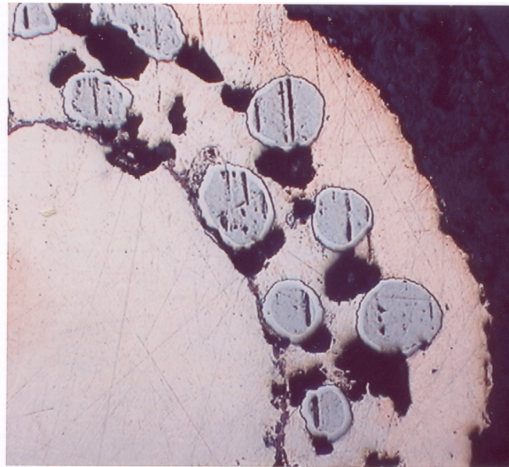


Fig. 1.8 ZAB1A #3, 175

ZAB1A #4

This was heat treated with 0.0305 grams Ag₀, 4 At. % in sample. The whole sample looks more symmetrical than in the case of #3. The core and the filaments are hard and of one phase. The hardness indentations are shown in Fig.1.11 and both the central core and the filaments are Rc 52, HV₂₅ 572. The obvious questions are why the hard core and is the hardness for the filament due to oxygen or Sn.

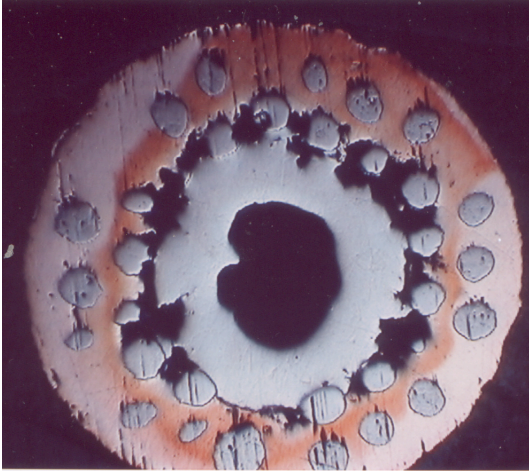


Fig. 1.9. ZAB1A #4

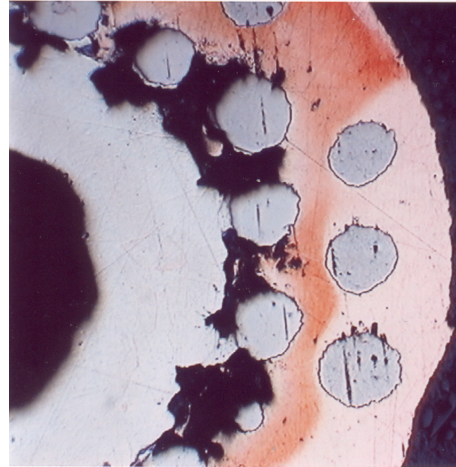


Fig. 1.10. ZAB1A #4 17 X

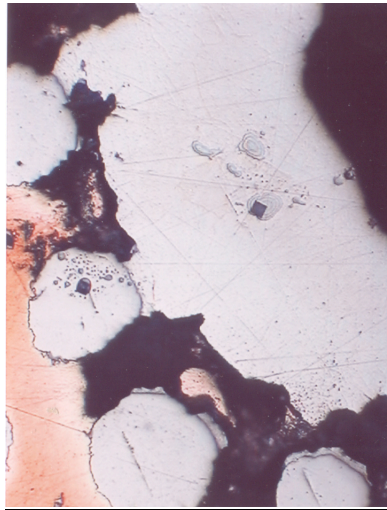


Fig. 1.11. Hardness indentations in ZAB1A #4

SEM Examination of ZAB1A#1 and ZAB1A#4

ZAB1A#1

Compositional traces of the three areas, X_1 , X_2 & X_3 in a filament are shown in Figs. 1.12 a, 1.12 b, 1.12 c & 1.12 d

These show that under these conditions normal Nb_3Sn formation is taking place but in addition an area with high (~50 wt.%) Sn and containing 10wt.%Cu in addition to Nb appears to have formed on the side of the filaments closest to the Sn source.

ZAB1A#4

In order to determine the source of the hardness which appears in both the filaments and the core in this material, SEM and EDX analysis was carried out on

two of the hard filaments, one of which showed a small surface area which appeared to have undergone reaction. The filament with no surface reaction, although hard, showed no evidence of Sn. The small surface area on the other did show some evidence of reaction.

The considerable difference between the results on ZAB1A #4 and those on ZAB1A/s 1-3 suggested that a serious tin leak had taken place, allowing oxidation to take place throughout the observed cross section. The opposite end of the same sample was examined and appeared to be similar.

It was decided to discontinue any further examination of these Phase I samples and to concentrate on oxidation experiments on Nb, Nb1Zr and OFHC and ETP Cu, until new composites have been produced.

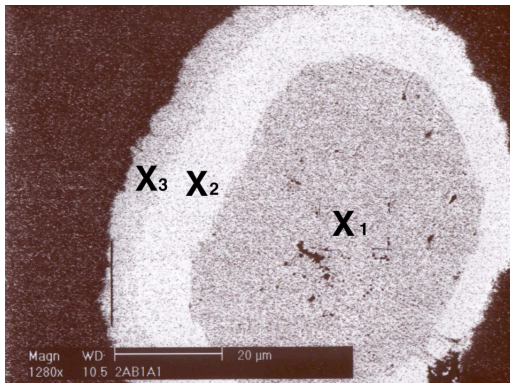


Fig. 1.12 a.

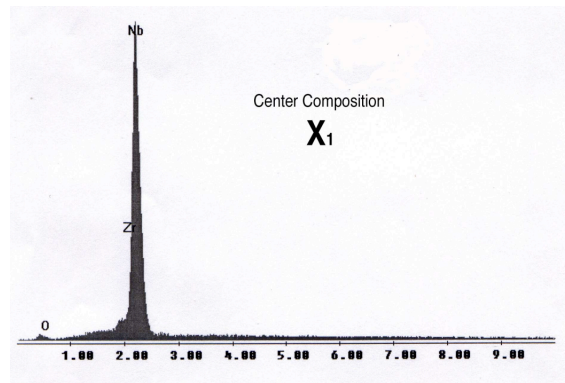


Fig. 1.12 b.

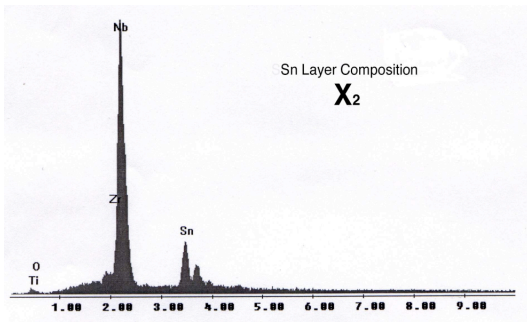


Fig. 1.12 c.

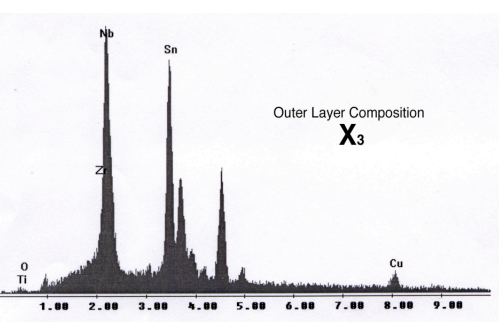


Fig. 1.12 d.

3. Methods of introducing O₂ into the Cu, Nb and Nb1Zr explored.

It appeared from the work on the Phase I ZAB1A #4 material that something, presumably oxygen, had significantly hardened the Nb1Zr filaments and also the Sn/Ti core. It was decided therefore to explore the direct exposure of Nb and Nb1Zr

to the same oxidizing environment that was used in the ZAB1A #2 experiment. Table II shows the conditions. Again the samples were sealed in quartz ampoules and the heat treatment conditions were: ramp to 180°C at 10°C/h, hold for 24h, ramp to 340°C at 5°C/hr, hold for 24h, ramp to 700°C at 25°C/h, hold for 47h and water quench.

In order to determine the extent to which oxygen could be introduced into OFHC and ETP Cu these samples were each heat treated under two different conditions: 450°C, 24h and water quench, 800°C, 24h and water quench (See Table III).

The copper samples developed a thick oxide composed of a black outer layer and a red-orange inner layer which increased in thickness with temperature. The oxide was removed using an abrasive tool prior to oxygen analysis being performed. The Nb 1Zr developed an outer layer which was visible as a more lustrous layer during the oxidizing treatment. It was also visible as an area in which the hardness was such that the abrasive SiC did not get imbedded during sample preparation Fig.1.13. This suggests a considerable penetration of O₂.

Oxygen analysis was carried out on all these samples both before and after the oxidizing treatment. Table IV shows the results.

Hardness tests were also carried out on the various samples at room temperature, 300°C, 400°C and 500°C. The results are shown in Figs 1.14-1.23. Fig. 1.14 shows the location of the region in which the hardness measurements were taken. Most readings were a long distance from the surface of the rods.

Table II							
	Sample ID	Diameter	Length	Mass	Powder	quantity grams in	
		in	in	grams		grams	grams
	ampoule						
d	Nb #1	0.1	1.75	1.94	none, control	-	-
e	Nb #2	0.1	1.875	2.1	Cu, Cu ₂ O, Al ₂ O ₃	2.1	1.5
f	Nb-1Zr #1	0.238	1.938	11.6	none, control	-	-
g	Nb-1Zr #2	0.238	1.813	11.14	Cu, Cu ₂ O, Al ₂ O ₃	8.1	8.1

Table III

Sample ID	Diameter in	Length in	Mass grams	Conditions
ETP Cu	0.25	1.75	12.53	air
OFHC Cu	0.25	1.75	12.53	air
ETP Cu#2	0.25	1.875	13.36	air
OFHC Cu #2	0.25	1.875	13.35	air

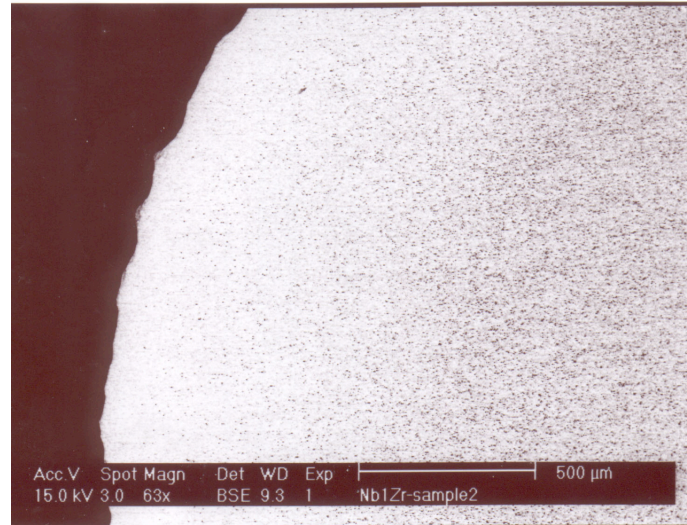


Fig. 1.13 Nb1Zr after oxidizing treatment showing different amounts of embedded SiC,

Table IV

As received	% Oxygen		Mean
Heat treated			
ETP Cu	0.0264	0.0260	0.0262
ETP Cu, 450C + air	0.0271		0.0271
ETP Cu, 800C + air	0.0270		0.0270
OFHC Cu	0.0001	0.0002	0.0002
OFHC Cu, 450C + air	0.0005		0.0005
OFHC Cu, 800C + air	0.0005		0.0005
Nb	0.0309	0.0308	0.0309
Nb, vacuum	0.0319	0.0328	0.0324
Nb, oxidized	0.1090	0.1140	0.1115
Nb-1Zr	0.0047	0.0032	0.0040
Nb-1Zr - vacuum	0.0060	0.0060	0.0060
Nb-1Zr, oxidized	0.1140	0.0861	0.1001

They do not cover the area which shows the lustrous condition in Fig.1.13. Fig.1.14 below shows how hardness traces at room temperature were obtained. A square sample was cut from the cylinder and polished. The first indentation was taken at 0.305 mm from the edge of the square. The resulting traces are shown below.

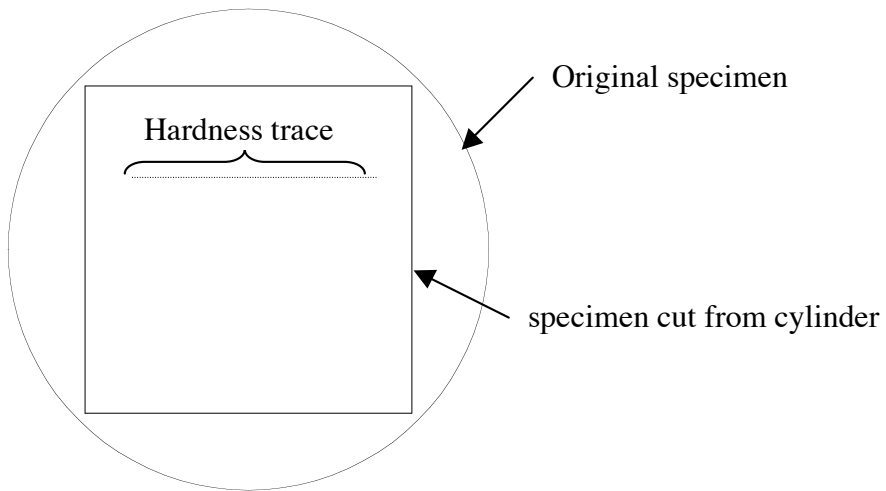


Fig.1.14. Locations of hardness traces

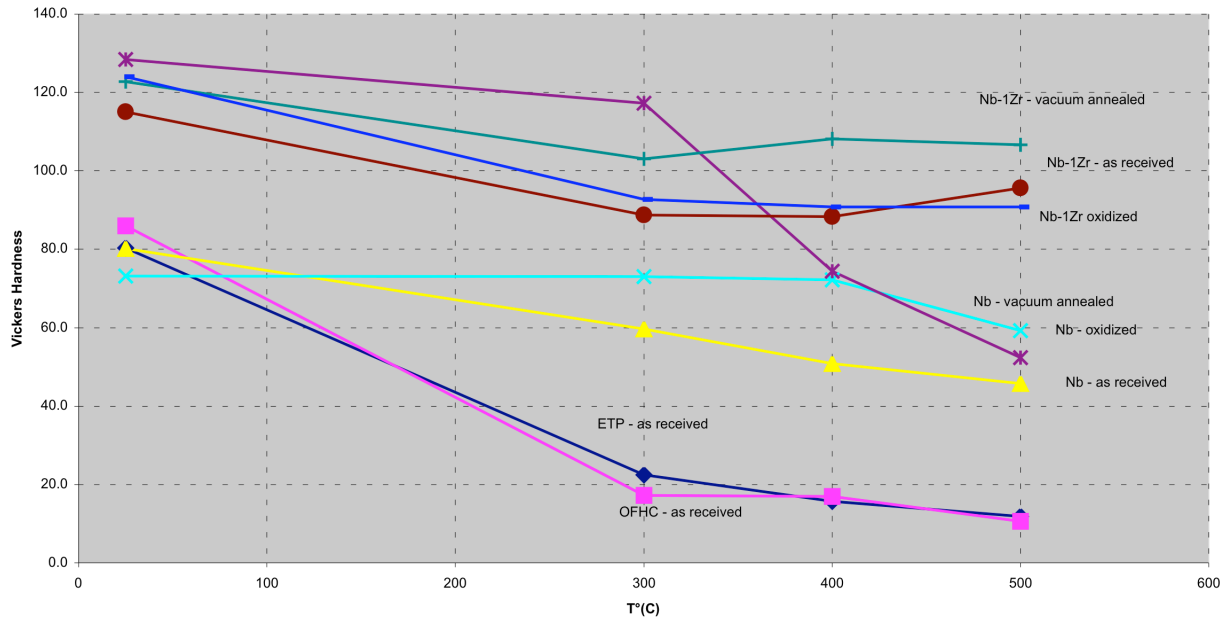


Fig. 1.15. Average Vickers hardness values and variation with temperature. The tests were conducted in a vacuum (order of 10^{-5} torr) using a load of 200 grams.

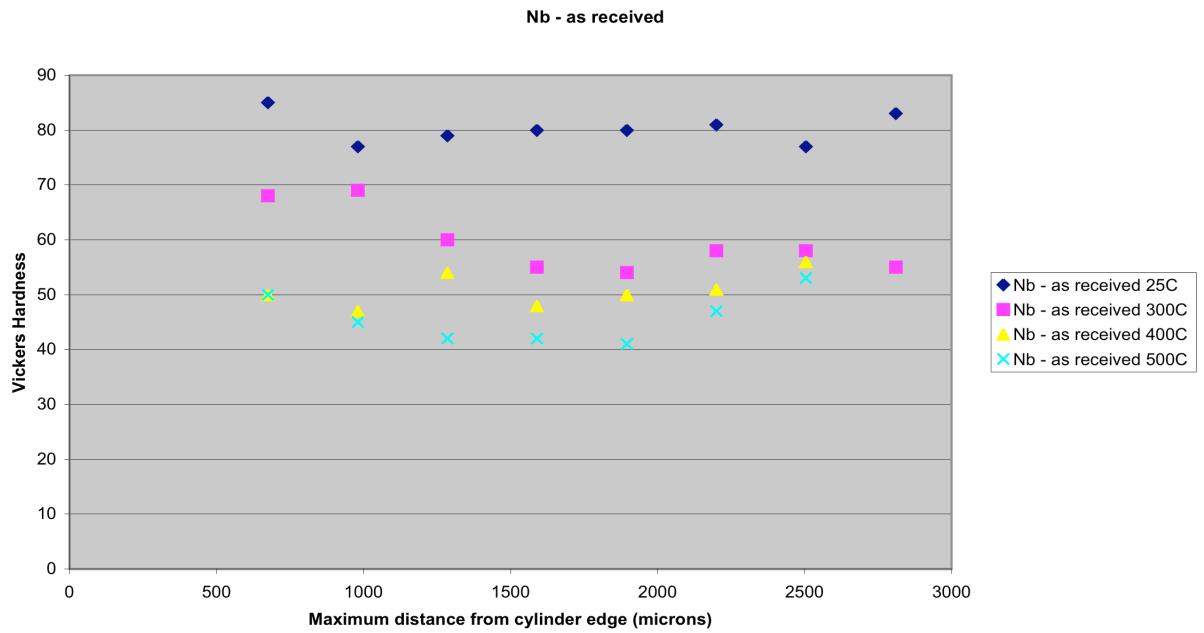


Fig. 1.16. Average Vickers harness starting Nb

Fig.1.17

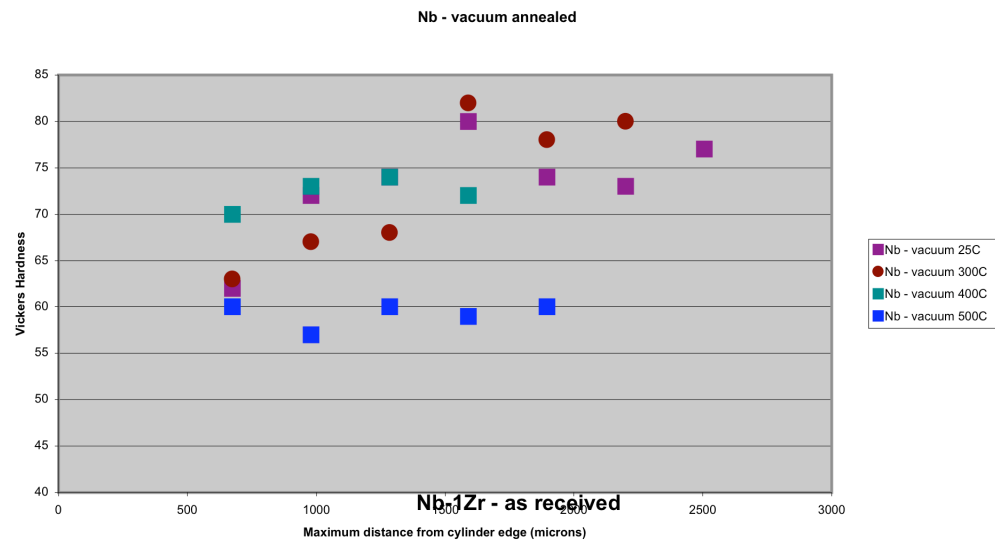


Fig. 1.18

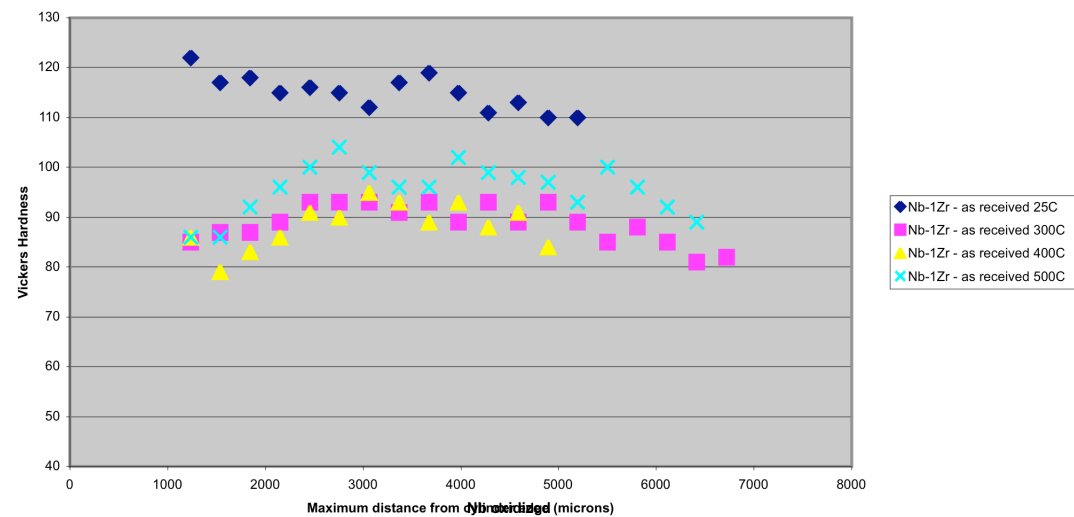
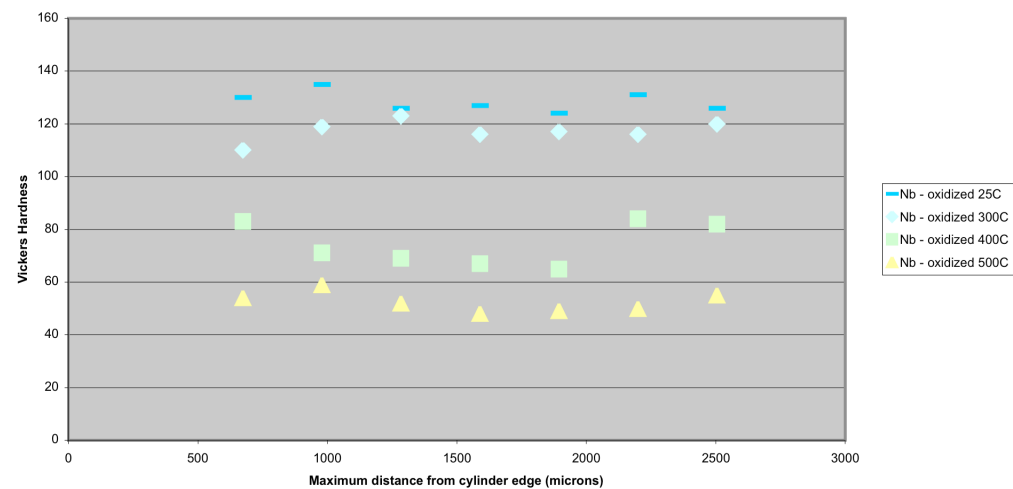


Fig.1.19



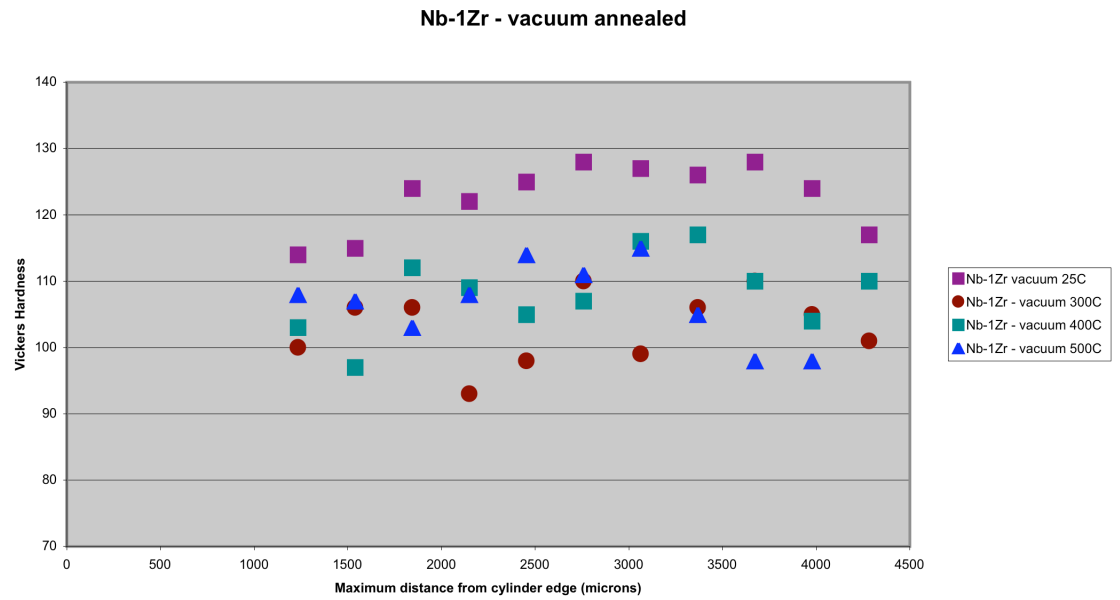


Fig.1.20

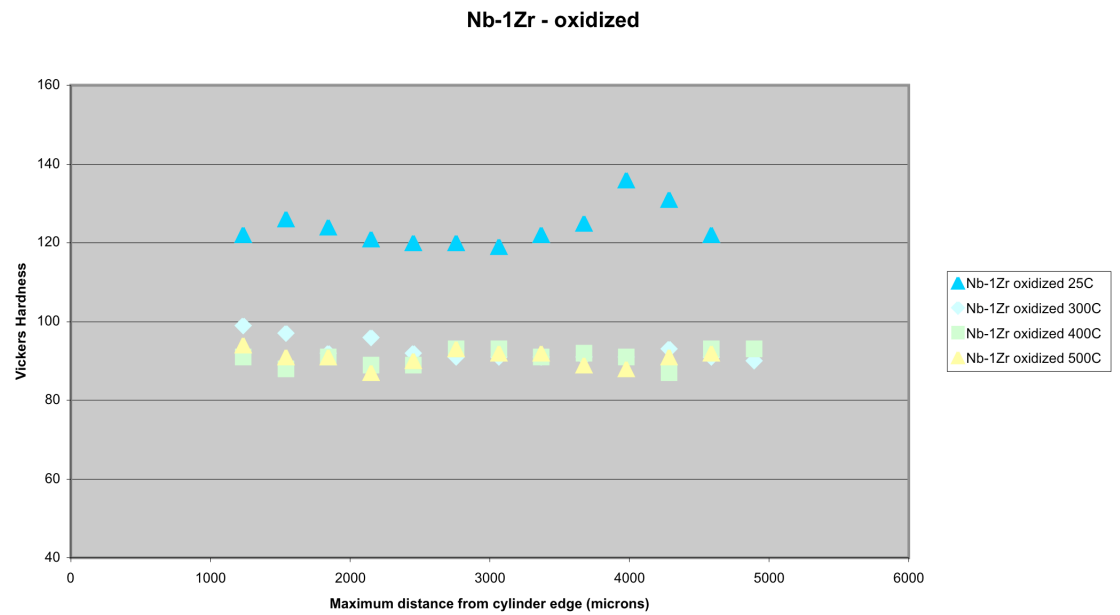


Fig.1.21

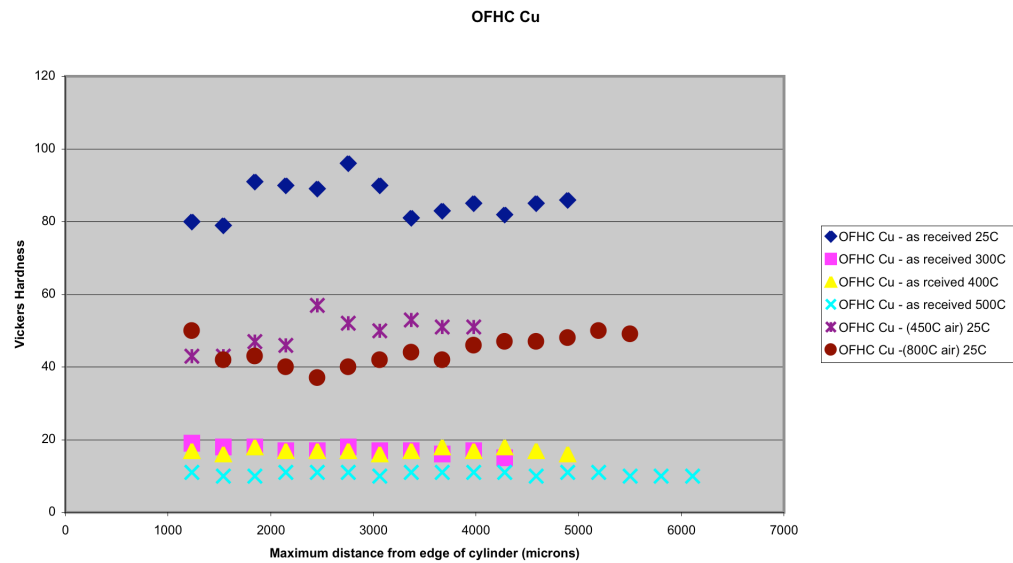


Fig.1.22

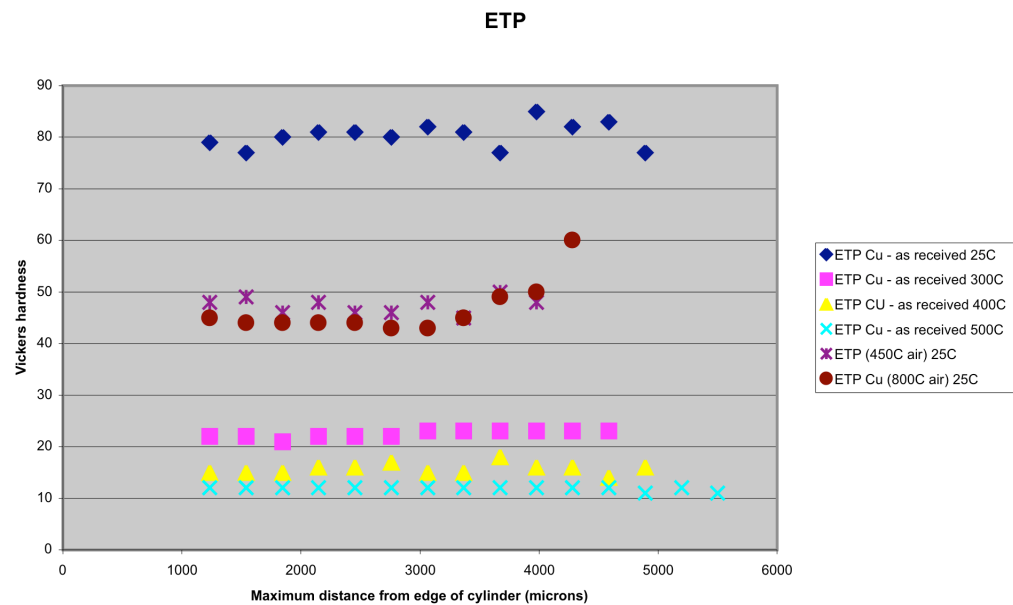
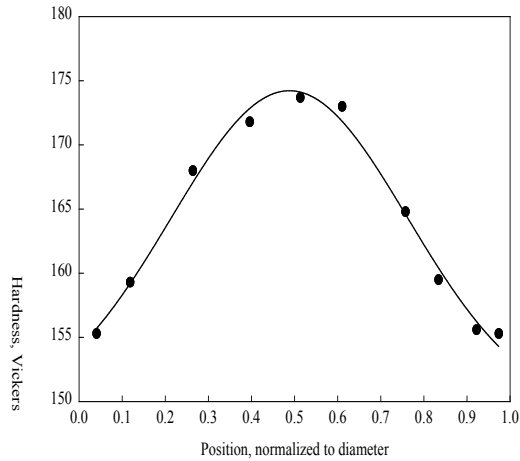


Fig.1.23

It was apparent from Fig. 1.13 that significant oxygen penetration had taken place in the Nb1Zr and this was not revealed in Fig. 1.21 as the hardness readings were not close enough to the surface of the rod.

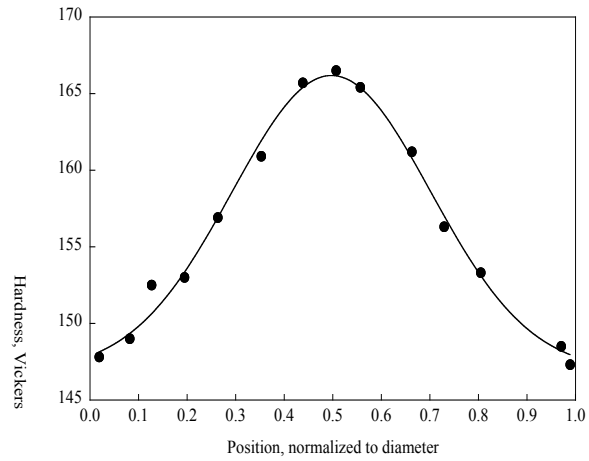
A series of hardness traces were made at OSU taking readings closer to the surface on the cross sections of both the Nb1Zr and the Nb. These traces of the Nb1Zr are shown in Figs. 1.24-1.26. The “as received” material was harder in the center than at the outside. This was only slightly lowered by the vacuum anneal and the distribution was

maintained. After the oxidation treatment the surface hardness was markedly increased but this would not have been detected in the work carried out at GE.



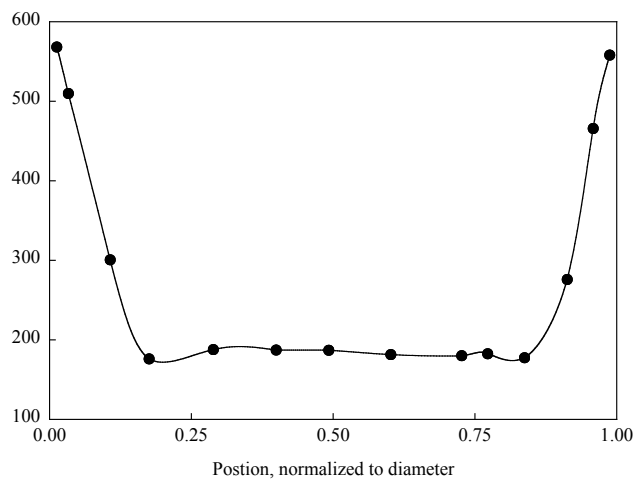
Hardness vs position for Sample A

Fig. 1.24 As received Nb1Zr



Hardness vs position for Sample 1

Fig. 1.25 Vacuum Annealed Nb1Zr



Hardness vs position for Sample 2

Fig.1.26 Oxidized Nb1Zr

Fig. 1.27 Shows the corresponding traces for Nb. Sample A is for the “as received “ material. Sample 1 is the vacuum annealed material and Sample 2 is the oxidized sample.

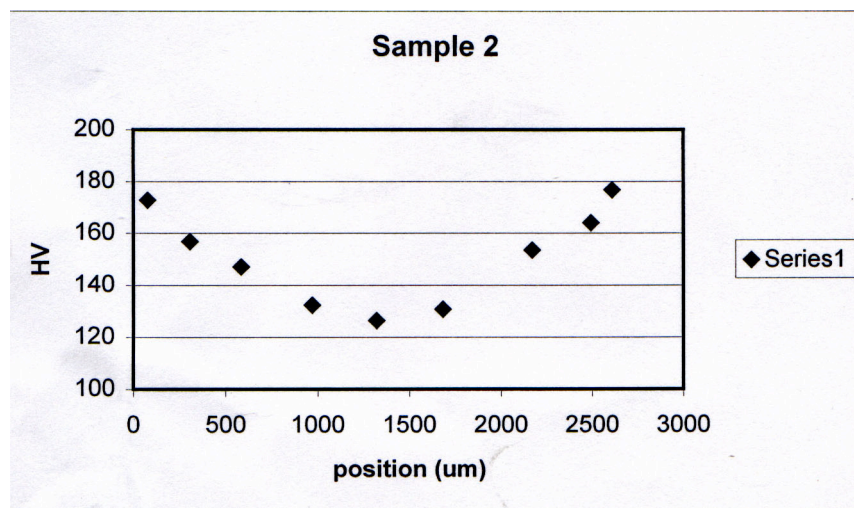
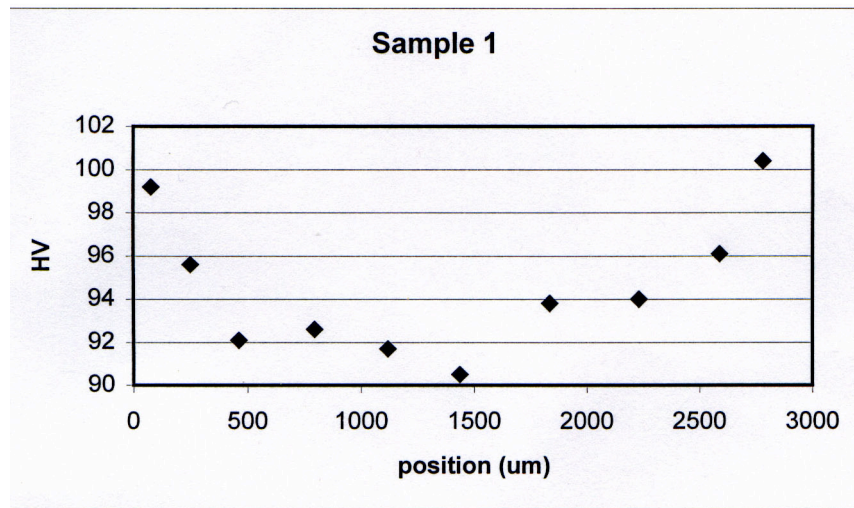
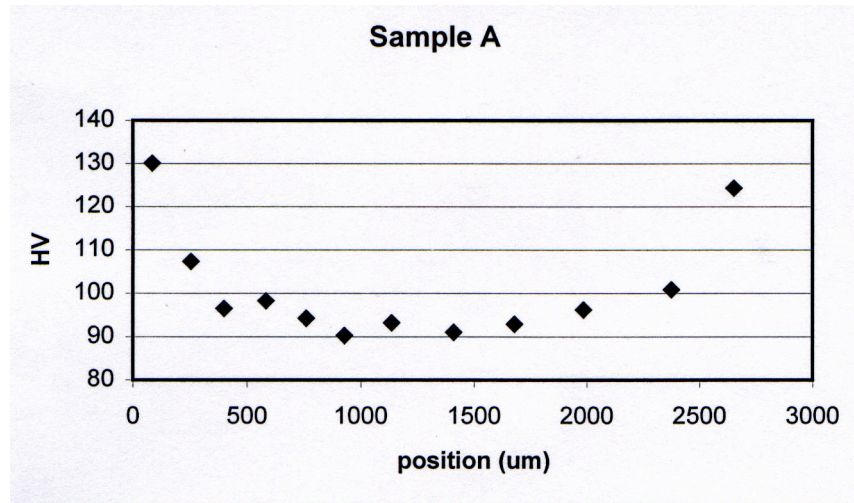


Fig. 1.27

The “as received” material has a higher surface hardness while a vacuum anneal reduces this somewhat but heat treatment in oxygen raises the overall hardness. Not to the extent though found in Nb1Zr. This presumably is due to the fact that in the Nb the interstitial oxygen is increased whereas in the case of the Nb1Zr, ZrO_2 dispersion is formed.

Fig.1.28 shows a cross section of the vacuum treated material and Fig. 1.29 one of the oxidized material. Fig.1.30 shows the latter at a higher magnification. These surface oxides were of course removed before the hardness traces in Fig.1.27 were taken.

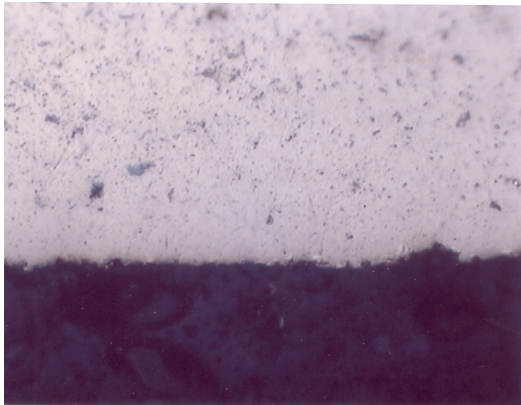


Fig. 1.28 C. S. Vacuum treated Nb X 925.

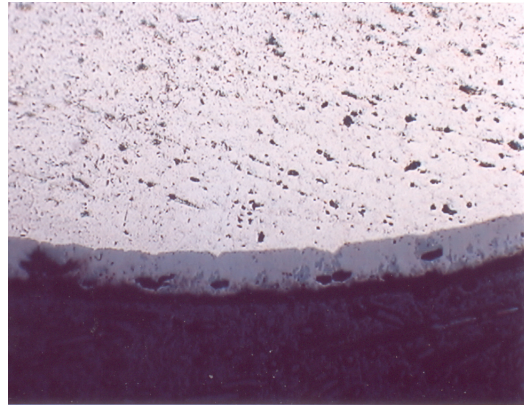


Fig. 1.29 C. S. of oxidized Nb X 175.

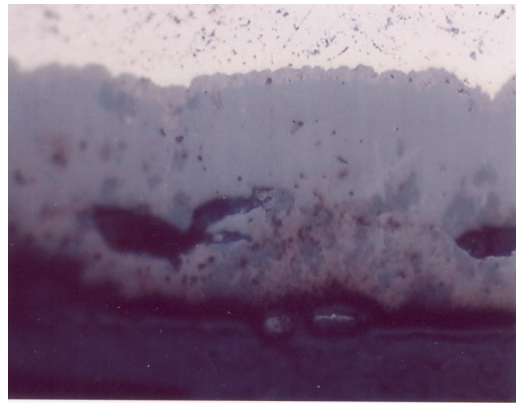


Fig. 1.30 Cross Section of oxidized Nb showing several different oxides X925.

Oxygen in the Copper

The results in Figs. 1.22 and 1.23 show that both the OFHC and ETP coppers showed no evidence from the hardness of oxygen penetration below the surface oxide that had been removed before taking the measurements. Since these measurements were also taken some distance from the surface, the samples after oxidation were carefully examined by optical metallography, SEM and EDX from close to the surface and inwards. No evidence of oxygen penetration was observed. It was concluded that storing

enough oxygen in the copper to internally oxidize the Nb1Zr in the later stages of the processing was not a viable option.

Alternative methods of introducing oxygen

A series of experiments were conducted designed to introduce oxygen through the Sn/Cu alloy that is inserted into the subelement after extrusion. The first attempt was to extrude a powder mixture of Sn and either Sn oxide or Cu_2O .

We also intend to explore the possibility of introducing oxygen into the Nb1Zr rods directly before extrusion. The aim is to get the oxygen into the alloy without hardening it to the point where it cannot be processed.

Two methods were tried and time and temperature variables explored:-

1. Heating the Nb1Zr rods at three different temperatures (700K, 900K and 1100K) in Nb_2O_5 for three different times. (This will provide the Oxygen at a slower rate)
2. Heating the Nb1Zr rods at 700°C in Cu_2O for three different times. (This is a faster rate process.)

Table V shows the matrix of conditions tried.

Table V

Base comp	Oxidizer comp	Time (hours)	Temp (K)
Nb-1Zr	Cu2O	0.5	700
Nb-1Zr	Cu2O	5	700
Nb-1Zr	Cu2O	50	700
Nb-1Zr	Nb2O5	0.5	700
Nb-1Zr	Nb2O5	0.5	900
Nb-1Zr	Nb2O5	0.5	1100
Nb-1Zr	Nb2O5	5	700
Nb-1Zr	Nb2O5	5	900
Nb-1Zr	Nb2O5	5	1100
Nb-1Zr	Nb2O5	50	700
Nb-1Zr	Nb2O5	50	900
Nb-1Zr	Nb2O5	50	1100

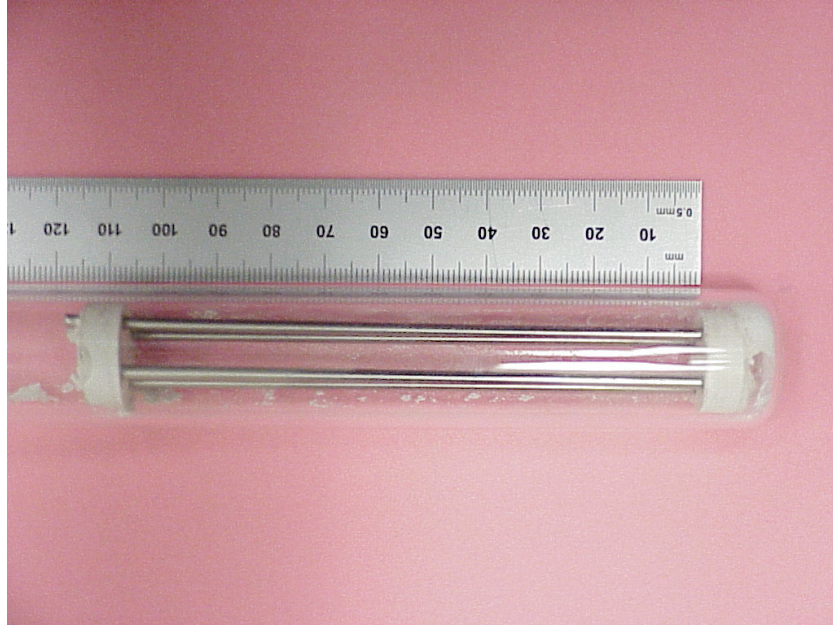


Fig 1.31 Ampoule with Nb1Zr rods and rod holder

2. 50.8mm (2") Ø billet preparation and extrusion.

In Phase I we successfully extruded at 450°C, a drilled billet 88.9mm (3.5") Ø to a bar 21.3mm (0.84") in diameter. This billet contained 35 rods of Nb1Zr in annealed and non-oxidized condition. Subsequent reduction by drawing resulted in badly "sausaged" filaments. Three conditions existed that may have caused part of the "sausaging" problem. We omitted to anneal the material after extrusion and, because the billet was drilled, the spacing between the filaments was too large to enable them to support one another, during the drawing process. In addition the die reduction schedule had to be adjusted to compensate for the large mismatch in yield strength of the materials.

After our successful extrusion Outokumpu tried to extrude two 203mm (8") Ø billets at higher temperatures and experienced problems similar to those we encountered when we tried to extrude at 800°C. Their billets had Cu clad hexed rods 3.25mm (0.128") flat-to-flat.

For our attempts to fabricate the non-oxidized material extruded one billet ahead of the rest to confirm the extrusion conditions. The billet had a diameter of 50.8mm (2") and contained Cu tubes with a hex OD 3.25mm (0.128") flat-to-flat and 2.44mm (0.96") Ø Nb1Zr rods. The design of the billet has been shown in Fig.1.1 and Fig. 1.32 shows the loaded billet before EB welding.

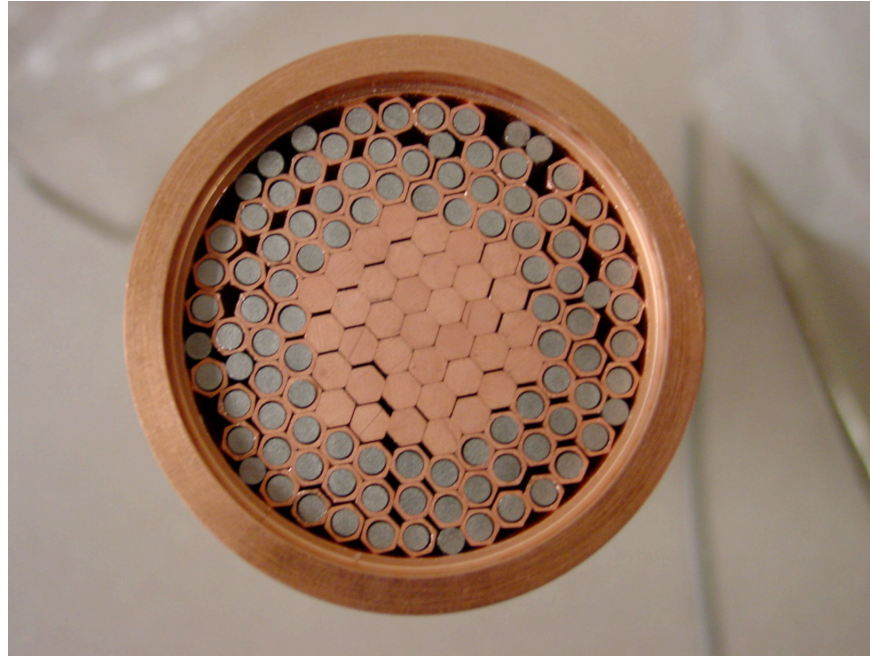


Fig. 1.32, 50.8mm (2") Ø billet before EB welding.

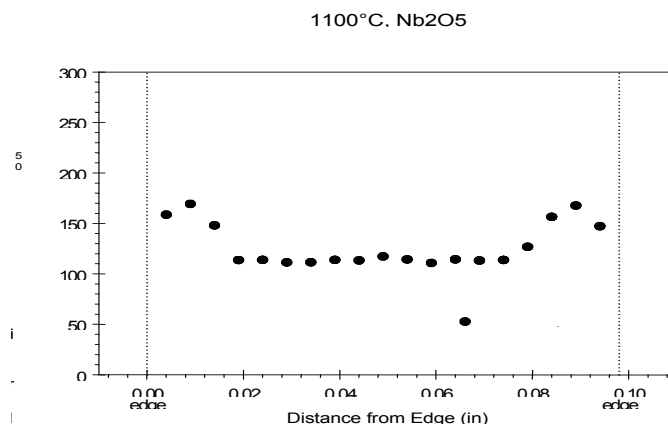


Fig. 1.33, Hardness across the Nb1Zr showing significant penetration of the oxygen 100 hrs. at 1100 °C.

We have learned and practiced the introduction of oxygen to the Nb1Zr starting rods by use of Nb₂O₅ powder as a source of oxygen at 1100 °C. Figure 1.33 illustrates the hardness profile of a starting Nb rod of 2.438 mm diameter after 100 hrs at 1100 °C with Nb₂O₅ powder as an oxidant. The y axis is the Vickers micro-hardness on the HV 500 scale. An average of 0.328 wt % of oxygen was introduced though mainly in the outer 30 % of the area.

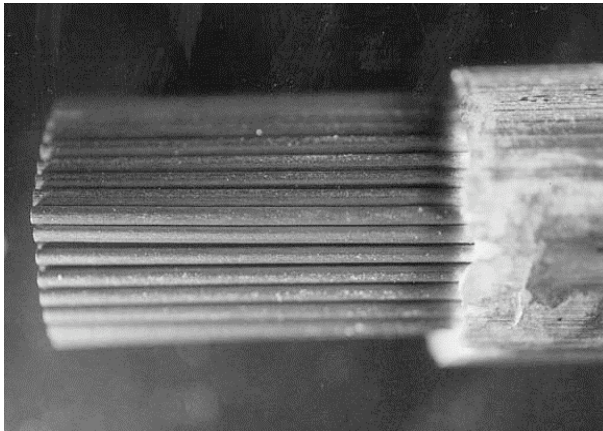
Summary

1. Sausaged filaments and tin leaks yielded inconclusive results on phase I material. Further efforts were focused on the new materials and billets.

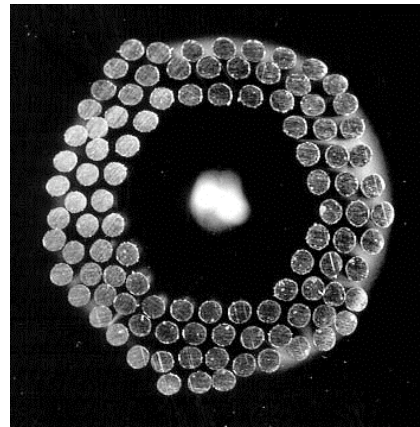
2. Use of copper as a carrier for oxygen is not practical. The solubility of Oxygen is too low when introduced by diffusion.
3. Oxygen introduced into the composite by adding Tin Oxide powder to the usual tin core and co-processing as per the MEIT process is a superior solution.
4. We have learned and practiced the introduction of oxygen to the Nb1Zr starting rods by use of Nb_2O_5 powder as a source of oxygen at 1100 °C.

8.2 Experiments to demonstrate the best extrusion and drawing conditions and produce material suitable for testing and evaluation.

ZAB3, a 51 mm diameter billet was successfully extruded to yield sound product using a low 450 °C extrusion temperature with a 17.4/1 extrusion ratio. A 1000 °C anneal was introduced after extrusion and the material was drawn with an initial draw schedule of 30%, 26% and then a standard 20.6% reduction. Final wire without breakage was produced at 0.254 mm with a Sn+SnO₂ core. Figure 2 a, and b shows the etched as extruded rod while Figure 3 a, and b show the cross section and etched filaments.

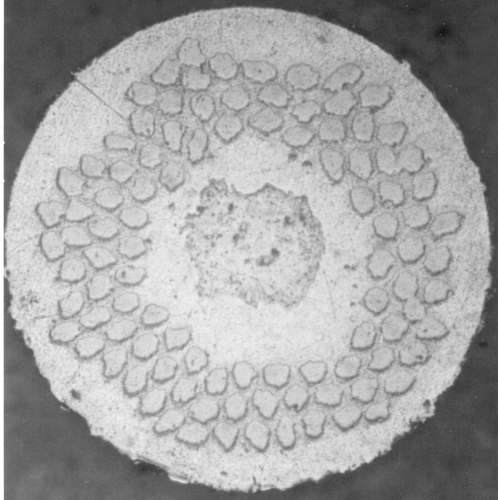


a.

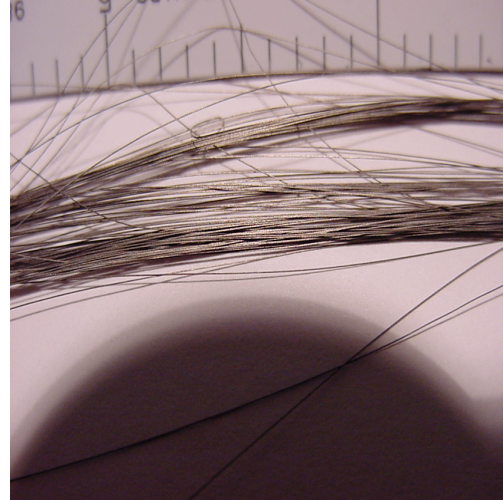


b

Figure 2. Filaments in the extruded condition – center section of the successful extrusion of ZAB3



a.



b.

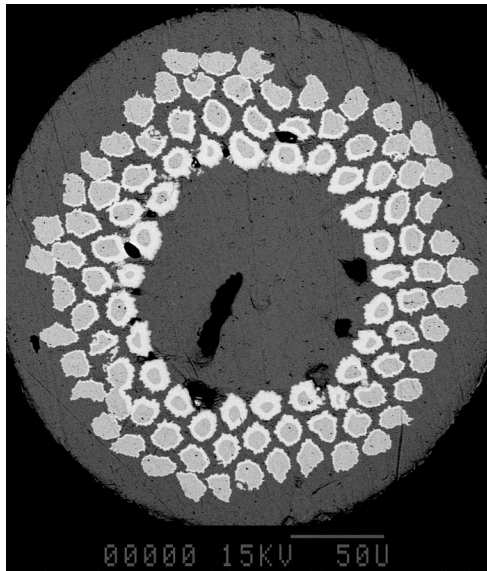
Figure 3 (a) -ZAB3 at 0.381 mm. Figure 3(b) - filaments of ZAB3 at 1.62 mm

Samples of ZAB3 with a Sn+Ti and Sn +SnO₂ core were heat treated for 24 hrs at 185 °C, 24 hrs at 375 °C and 48 hrs at 700 °C using ramp rates of 10 °C, 10 °C and 50 °C per hour respectively. Three types of powder were added externally, CuO₂, Nb₂O₅ and Ag₂O as well as a control without additional powder. Table I gives the results of oxygen absorbed. The material with the Sn+SnO₂ core showed signs of cracking leading to leakage of the Sn. The lack of a circumferential Nb barrier combined with the vapor pressure of the oxygen was thought to have contributed to the failure.

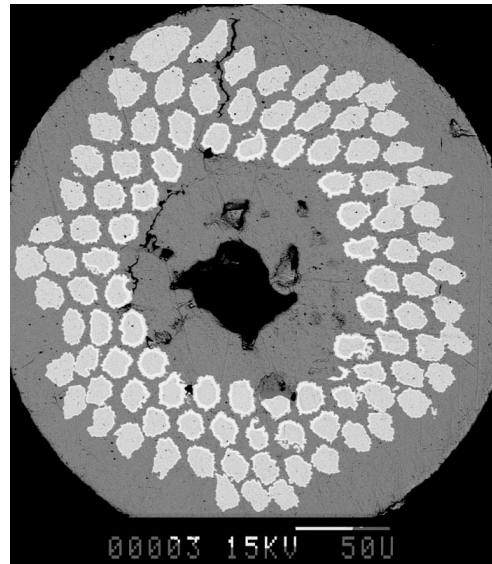
Table I

Sample	Oxidizing powder	Oxygen content wt%	Observation
#2. Sn + SnO ₂ core	None	0.162	burst
#4. Sn + SnO ₂ core	CuO ₂	0.692	burst
#6. Sn + SnO ₂ core	Nb ₂ O ₅	0.326	burst
#8. Sn + SnO ₂ core	Ag ₂ O	0.972	burst
#1. Sn + Ti core	None	0.046	sound
#3. Sn + Ti core	CuO ₂	0.209	sound
#5. Sn + Ti core	Nb ₂ O ₅	0.101	sound
#7. Sn + Ti core	Ag ₂ O	0.965	sound

Figure 4 a shows the reacted cross section of #1 with a Sn + Ti core. The Sn content of these billets was only 4.5 At % giving a bronze of 5.6 At % insufficient to fully react the filaments. Figure 4 b. shows #2 with a Sn+ SnO₂ core with cracks in the copper. This allowed the tin to leak out reducing the amount of reaction. The resulting difference in tin content makes comparison of the reaction amounts and grain size between the samples unsound. What can be seen though is that Oxygen was successfully introduced both through internal and or external means.

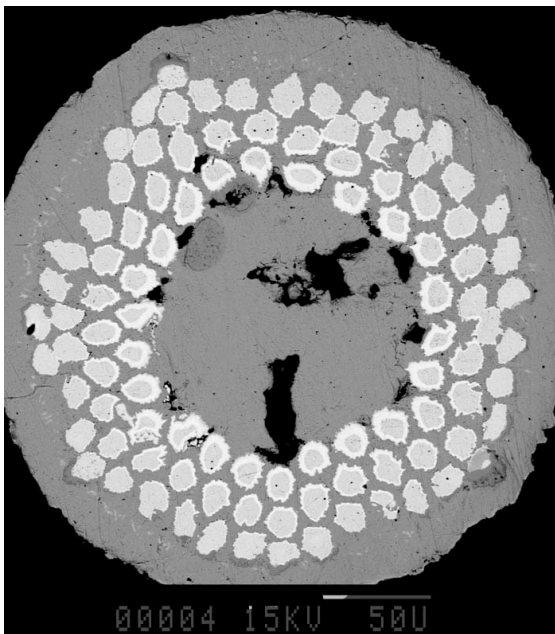


a.

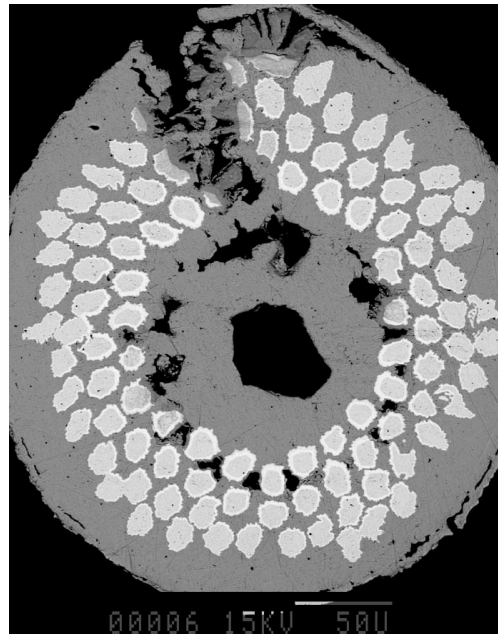


b.

Figure 4 (a) #1 ZAB3 wire reacted and (b) #2 reacted showing crack and less reaction due to tin leakage



a.



b.

Figure 5 (a) #7 ZAB3 wire reacted and figure 5 (b) #8 ZAB3 reacted showing a large burst area.

SEMs of the samples were obtained of the fractured surface to see if there was a difference in grain size. Figure 6(a). and 6(b). are typical but do not indicate much difference if any between the various samples.

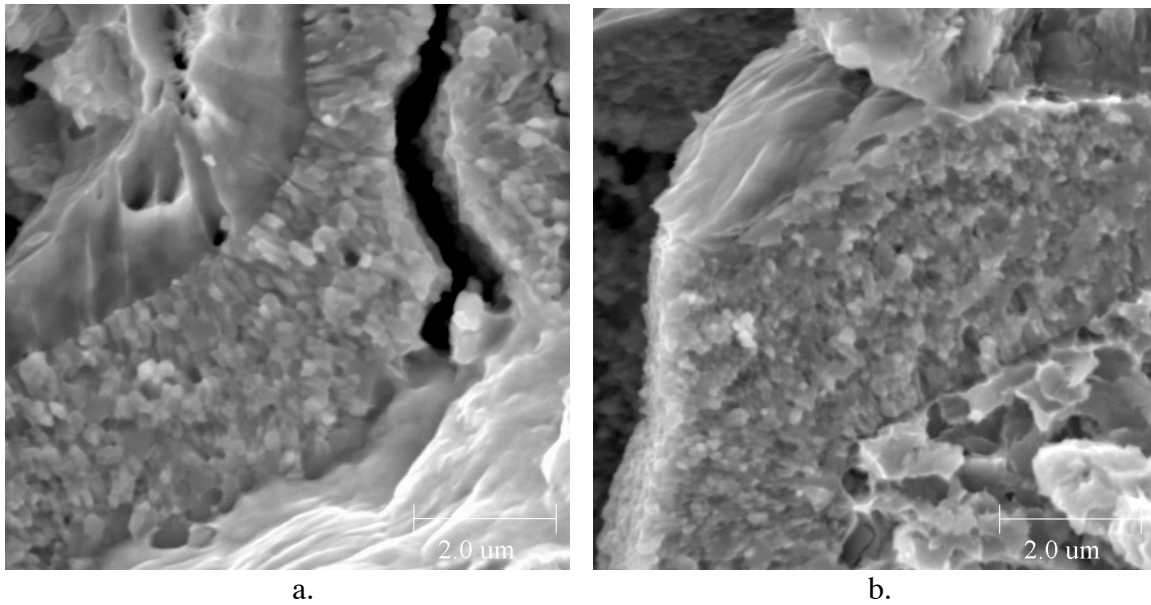


Figure 6 (a) SEM at 14KX of #7 ZAB3 Nb₃Sn grains, (b) is #8 ZAB3 with same parameters

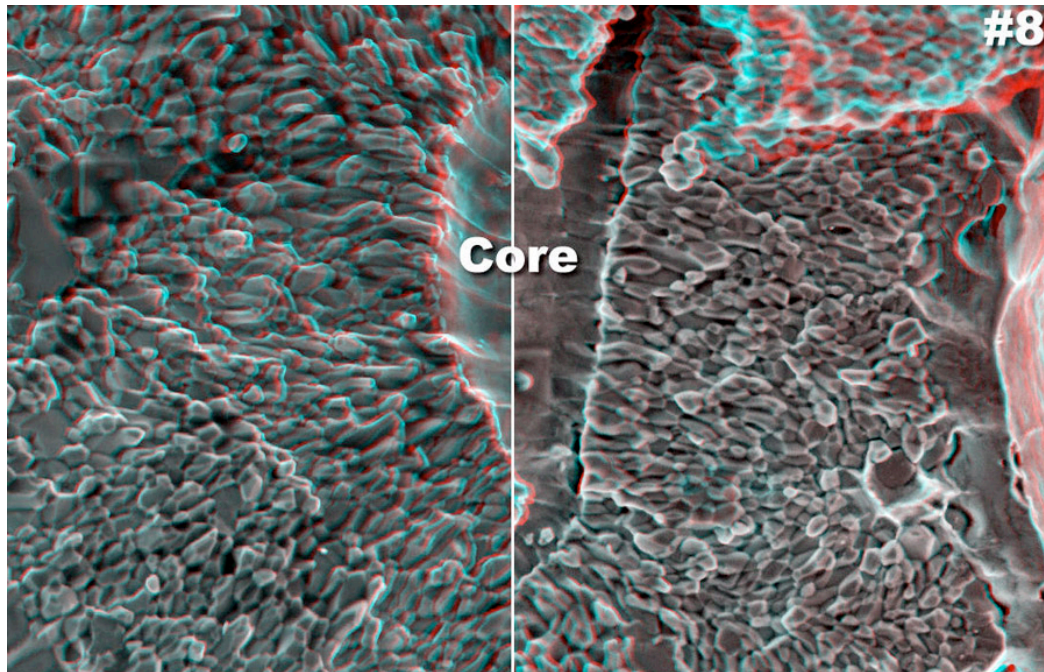


Figure 7, Steroscopic SEM courtesy of P. Lee of University of Wisconsin of #8 ZAB3 and #2 ZAB3 with no oxygen (left).

Figure 7 is a view provided by P. Lee of the University of Wisconsin. Because of the low tin content as well as position of the filaments and their varying degree of reaction we can not draw any conclusions from the SEMs.

ZAB4, a billet which incorporates a diffusion barrier, was used to evaluate the effect of oxygen not only through SEM analysis but also through critical current measurements. ZAB4, an 88.9 mm diameter billet, was assembled with 258 filaments of Nb1Zr, extruded to 22.22 mm, annealed at 975 °C for one hour, gun drilled with a 8.255 mm diameter hole, tin core inserted and drawn to 0.254 mm diameter wire. The initial draw schedule was 17.4%, 30%, 30%, and then a standard 20.6% reduction. The as extruded rod had to be turned more than usual to allow gun drilling. Copper stabilizer was 17.3%. Three tin cores, pure Sn, Sn+Ti, and Sn+AgO₂ were inserted. Some breakage was encountered with the AgO₂ core. Figure 8 is ZAB4 with a Sn + AgO₂ core at 3.25 mm. The array looks quite good.

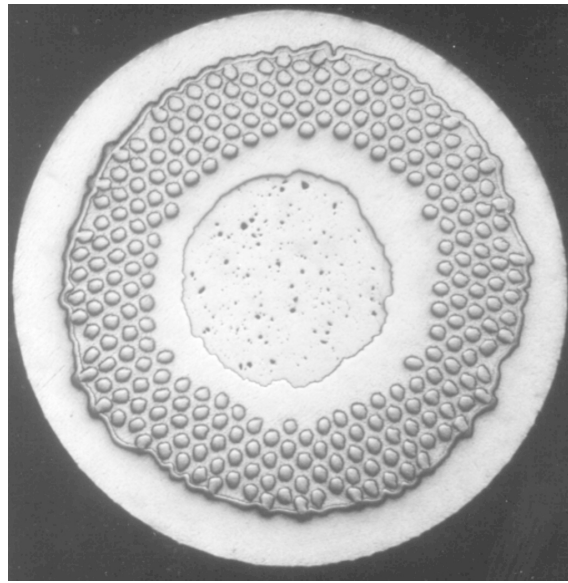


Figure 8. ZAB4 at 3.25 mm diameter with a Sn+AgO₂ core and diffusion barrier

Samples of ZAB4 wire at 0.254 mm wire were prepared with three cores composed of SnCu, Sn+1%Ti, and a Sn+2.5wt%SnO₂. The SnO₂ is sufficient to react all the Zr in the Nb1Zr rod. The heat treatment matrix is shown in table II. Samples were homogenized for 24 hrs. at 185 °C with a 10 °C/hr ramp rate then followed by 24 hrs at 375 °C with a 10 °C ramp rate and then ramped to the respective temperature at 50 °C/hr. A variety of times and temperatures were chosen to help build a model for grain size growth to compare with the original work done on Nb₃Sn tape by M. Benz et al.

Table II
ZAB4 Heat Treatment Matrix for Wire at 0.254 mm

Sample Core	700 °C	775 °C	850 °C	1000 °C
Sn+Ti	1,10,100 hrs	3 hrs	1,10 hrs	1 hr
Sn+Cu	1,10,100 hrs	3 hrs	1,10 hrs	1 hr
Sn+SnO ₂	1,10,100 hrs	3 hrs	1,10 hrs	1 hr

The reacted samples of Sn+Cu and Sn+Ti looked very similar for all temperatures so comparison pictures will not be included except at 1000°C where there was significant difference. Figure 9 and 10 show significant difference at 1000°C between the samples with Oxygen vs. those without. It appears in figure 9 that the filaments have lost most of their identity presumably because of the large grain size. Figure 10, the sample with oxygen, on the other hand maintains its filament identity showing the impact of the oxygen on reaction. For lower temperatures the oxygen appears to slow the reaction kinetics. The Sn+Ti sample at 850 °C for 1 hr. is fully reacted as seen in figure 11. The Sn+SnO₂ shows less reaction as seen in figure 12. At 700 °C for 10 hrs comparison between the samples figures 13 and 14 again show that reaction is slower with oxygen than without. There is similar amount of Sn in all samples and as can be seen in figure 10 sufficient to fully react the sample with Sn+SnO₂.

All of the samples were analyzed at GE CR&D for filament diameter, unreacted core diameter, and average reaction layer thickness. About 50 filaments were used for most of the analysis. It is interesting that for the 700°C Ti does not appear to influence the growth rate as compared to Sn+ Cu. Table III, ZAB4 Reaction Area, presents the data used to calculate actual current density in the layer. Fully reacted samples have no core diameter data in the table.

The above samples were taken to Smartech for fractographs to allow grain size analysis. Figures 15,16 and 17 respectively show the significant differences between the grain size of the samples at 1000°C for 1 hr. The Ti sample has the largest grain size while the Oxygen sample is significantly smaller. In contrast, at 700, 775 and 850°C there is little if any statistical difference. Table IV, Grain Size of ZAB4, presents the grain size data measured on one filament. Grain size analysis was done by GE and measures both radial and transverse direction. What is interesting though as can be seen from the table is that at 700°C for 10 hrs grain size is between 85 and 101 nm, relatively small as gleaned from the literature. This could be a result of the effect of the Zr addition which may have some ZrO₂ already precipitated from the residual oxygen in the starting rods. We do not know how much ZrO₂ is necessary to refine the grain.

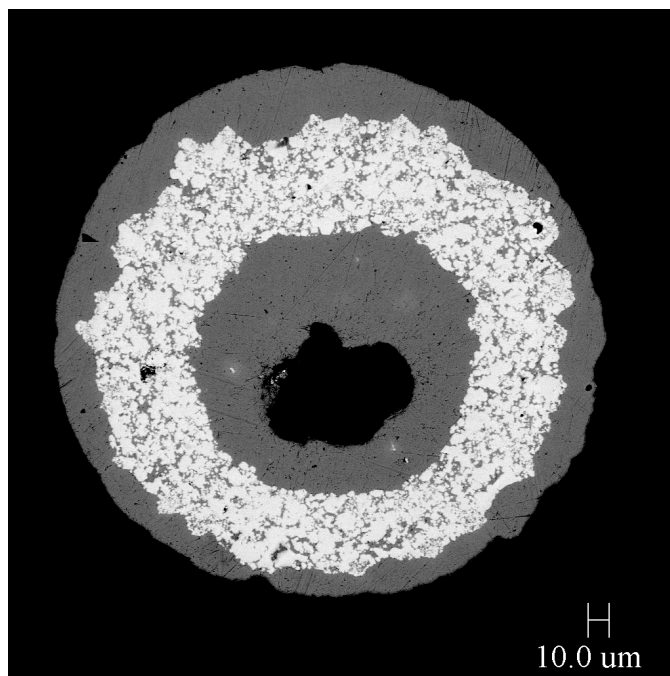


Fig. 9. ZAB4 CuSn core 1hr-1000°C (350x)

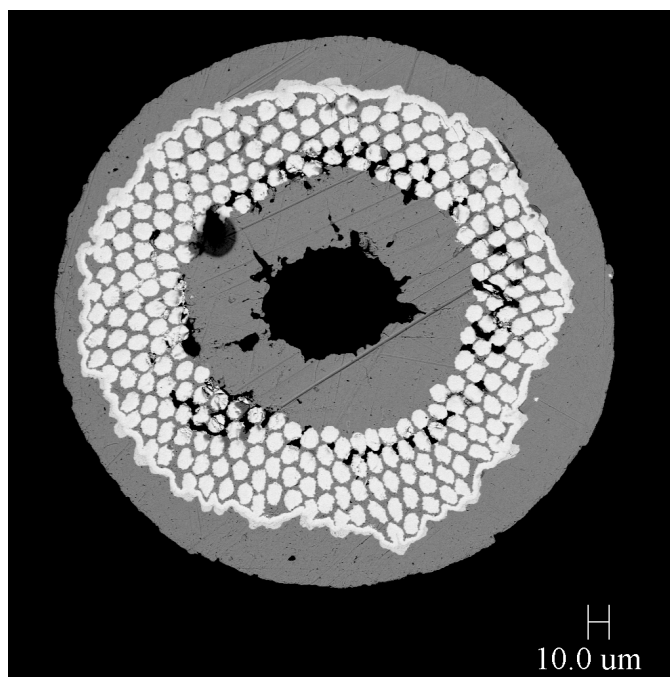


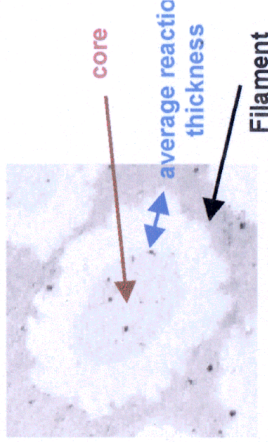
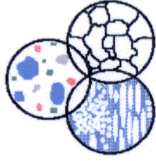
Fig 10. ZAB4 Sn+SnO₂ core 1 hr 1000°C (350x)

Table II: AB4 Reaction Area

GE Global Research Center
Microstructural and Surface Sciences Laboratory



Image Analysis



PO Box 8, Building K-1, Room 1C22, Schenectady, NY 12301, 518-387-6303; Fax -6972; Dialcomm 8-833-6303, Email: grande@crd.ge.com

Customer: Judson Marte
Material: superconductor

Magnification: 2kx
Resolution: 0.06 $\mu\text{m}/\text{pixel}$

Identification	Filament						Average Reaction Thickness (μm)					
	Fiber Diameter (μm)			Core Diameter (μm)			Average Reaction Thickness (μm)			Average Reaction Thickness (μm)		
	Mean	Std. Dev.	Min.	Max.	Mean	Std. Dev.	Min.	Max.	Mean	Std. Dev.	Min.	Max.
ZAB4_A1	8.35	0.24	7.82	9.12	5.36	0.32	4.51	5.88	1.49	0.12	1.13	1.81
ZAB4_A2	8.20	0.32	7.63	9.39	5.77	0.35	4.95	7.13	1.21	0.14	0.96	1.60
ZAB4_A3	8.30	0.23	7.73	8.90	6.35	0.28	5.06	6.87	0.97	0.13	0.76	1.71
ZAB4_B1	8.75	0.34	8.19	9.73	2.62	0.49	1.83	3.75	3.07	0.22	2.54	3.49
ZAB4_B2	8.73	0.25	8.23	9.31	2.23	0.54	1.09	3.23	3.25	0.31	2.65	3.88
ZAB4_B3	8.46	0.68	7.81	11.76	4.76	0.90	0.33	6.58	1.78	0.36	0.94	2.73
ZAB4_C1	8.91	0.60	8.04	12.44					NA			
ZAB4_C1	8.65	0.36	7.99	9.31								
ZAB4_C3	8.86	0.24	8.35	9.56	2.00	0.52	0.99	2.99	3.45	0.30	2.86	4.02
ZAB4_D1	9.20	0.33	8.79	10.27					NA			
ZAB4_D2	9.14	0.28	8.73	9.66					NA			
ZAB4_D3	9.16	0.28	8.51	9.71	1.77	1.23	0.33	4.58	3.72	1.06	0.17	5.75
ZAB4_E1	9.17	0.31	8.66	9.64					NA			
ZAB4_E2	8.81	0.25	8.29	9.24								
ZAB4_E3	9.17	0.29	8.45	9.74	1.92	1.04	0.49	3.87	3.63	0.64	2.36	4.58
ZAB4_F1	8.81	0.20	8.44	9.24					NA			
ZAB4_F2	8.85	0.29	8.31	9.43								
ZAB4_F3	8.65	0.30	7.97	9.41	2.92	0.64	1.12	4.30	2.87	0.35	2.11	3.75
ZAB4_G3	8.86	0.31	8.04	9.35					NA			

Table IV Grain Size (nm) of ZAB4

Mag 34 kx, Resolution 7.25 nm/pixel

grain size radial direction

Ident	Core	Temp (°C)	time (h)	Mean	Std. Dev.	Median	Min.	Max.	Mean	Std. Dev.	Median	Min.	Max.	Aspect Ratio	Avg Dia.
A1	Sn-Ti	700	1	66	19	62	30	152	82	40	73	27	428	1.25	74
A2	Sn-Cu	700	1	59	23	53	27	197	79	40	66	27	291	1.34	69
A3	Sn-SnO	700	1	64	20	60	30	135	78	25	73	36	176	1.22	71
B1	Sn-Ti	700	10	70	29	63	29	221	100	29	63	29	221	1.42	85
B2	Sn-Cu	700	10	76	28	72	29	222	127	28	72	29	222	1.67	102
B3	Sn-SnO	700	10	61	23	58	23	207	117	23	58	23	207	1.91	89
F1	Sn-Ti	700	100	137	37	130	49	283	232	99	216	65	594	1.70	184
F2	Sn-Cu	700	100	122	35	117	48	293	189	78	172	58	454	1.55	155
F3	Sn-SnO	700	100	141	40	140	65	351	235	102	217	58	624	1.67	188
C1	Sn-Ti	775	3	127	48	120	36	382	248	143	226	46	740	1.96	187
C1	Sn-Ti	775	3	161	55	146	65	373	321	138	297	80	848	2.00	241
C3	Sn-SnO	775	3	157	51	153	43	356	246	118	221	36	689	1.56	202
D1	Sn-Ti	850	1	232	92	215	105	557	364	177	345	96	1081	1.57	298
D2	Sn-Cu	850	1	210	111	183	51	869	210	111	183	51	869	1.00	210
D3	Sn-SnO	850	1	288	90	283	95	634	537	238	494	111	1531	1.86	413
E1	Sn-Ti	850	10	367	170	334	143	1158	560	267	496	177	1648	1.53	463
E2	Sn-Cu	850	10	324	141	294	130	851	461	208	432	114	1167	1.42	392
E3	Sn-SnO	850	10	320	128	299	111	976	493	226	452	127	1626	1.54	406
G1	Sn-Ti	1000	1	1299	709	1295	355	3027	2004	722	1971	1111	3612	1.54	1652
G2	Sn-Cu	1000	1	706	276	646	341	1609	1182	579	996	499	3298	1.67	944
G3	Sn-SnO	1000	1	568	210	534	223	1317	871	308	816	335	1759	1.53	719

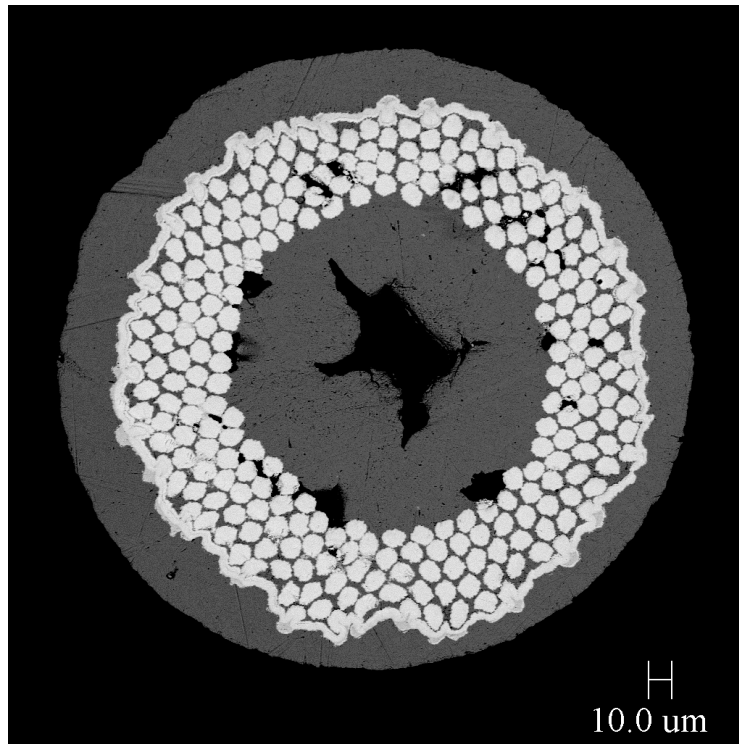


Fig.11 Fully reacted Sn+Ti core 850°C 1 hr. (350x)

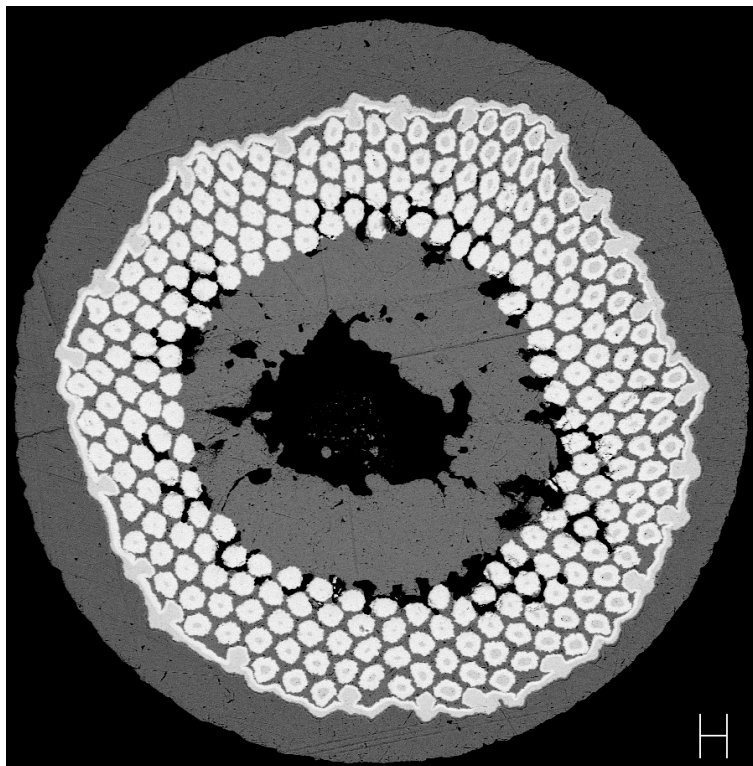


Fig.12 Partially reacted Sn+SnO₂ core 1 hr 850°C (350x)

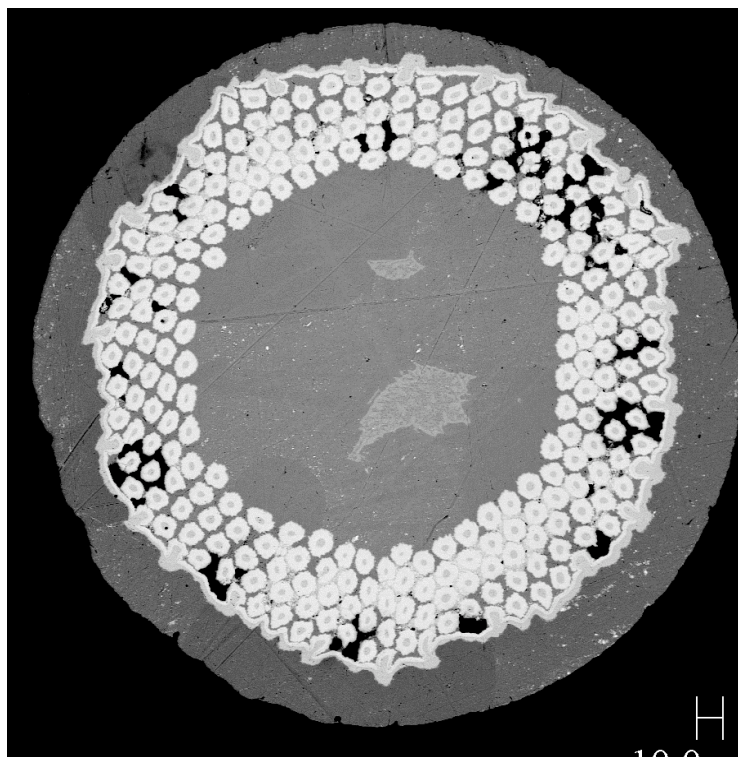


Fig.13 ZAB4 Sn+Ti core partially reacted 10 hr 700°C (350x)

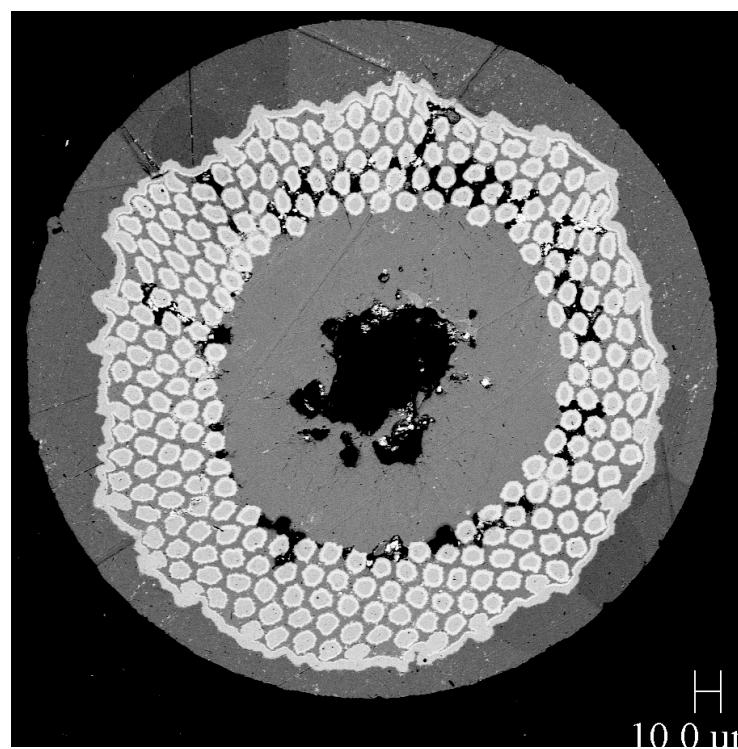


Fig.14 ZAB4 partially reacted Sn+SnO₂ core 10 hrs 700°C (350x)

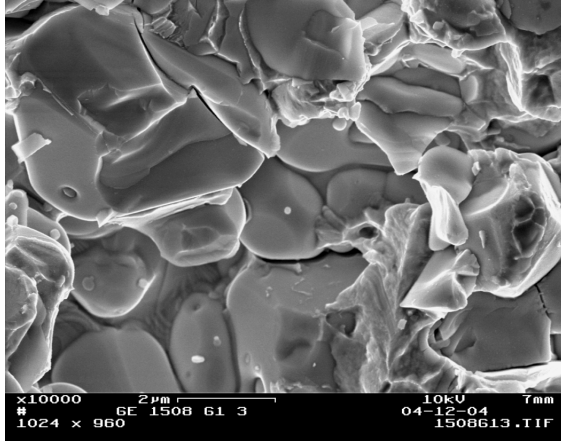


Fig.15. ZAB4 Sn+Ti core 1 hr 1000°C

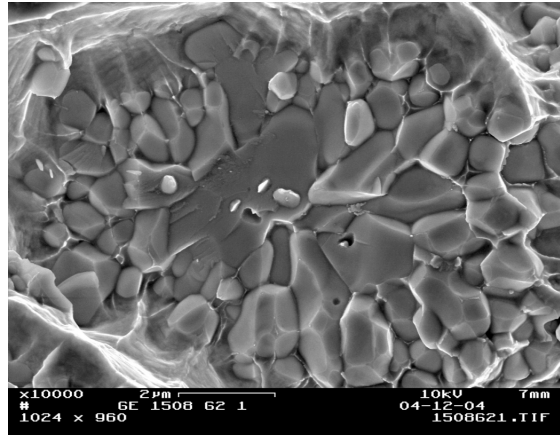


Fig. 16. ZAB4 Sn+Cu core 1 hr 1000°C

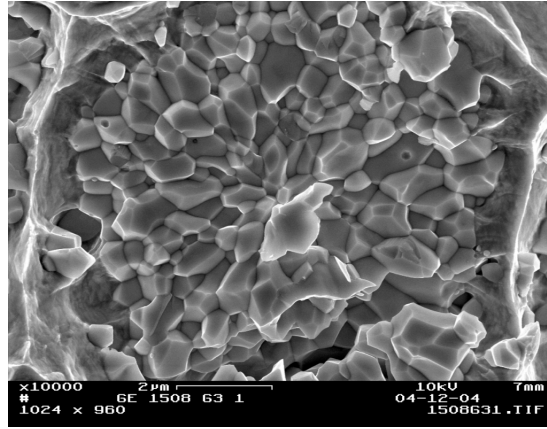


Fig. 17. ZAB4 Sn+SnO₂ core 1 hr 1000° C

The samples of ZAB4 with the heat treatments as listed in table II were tested at LBL by the P.I. and Dr. Dan Dietderich from 10 to 15 T on a holder designed to test short straight lengths. Some quenching was encountered especially in the higher current density samples. Table V presents the billet design parameters from which the overall current density was computed. Table VI takes the SEM data and summarizes the reaction area and grain size used in computing the layer current densities derived from the LBL measurements. Figure 18 presents the J_c vs. H for the Sn+Ti samples and the Sn +O samples for the times and temperatures as given in table II. Figure 19 presents J_c vs. H for the Sn+Cu vs. the Sn+SnO₂ samples.

Table V
Billet Design Parameters for ZAB4

Billet	Nb at%	Sn at%	Cu at%	Nb/Sn
ZAB4 #258 Nb1Zr, Ti and Cu +Sn	25.4	12.1	62.5	2.06/1
Sn+SnO ₂ Core	25.1	10.6	63.5	2.37/1

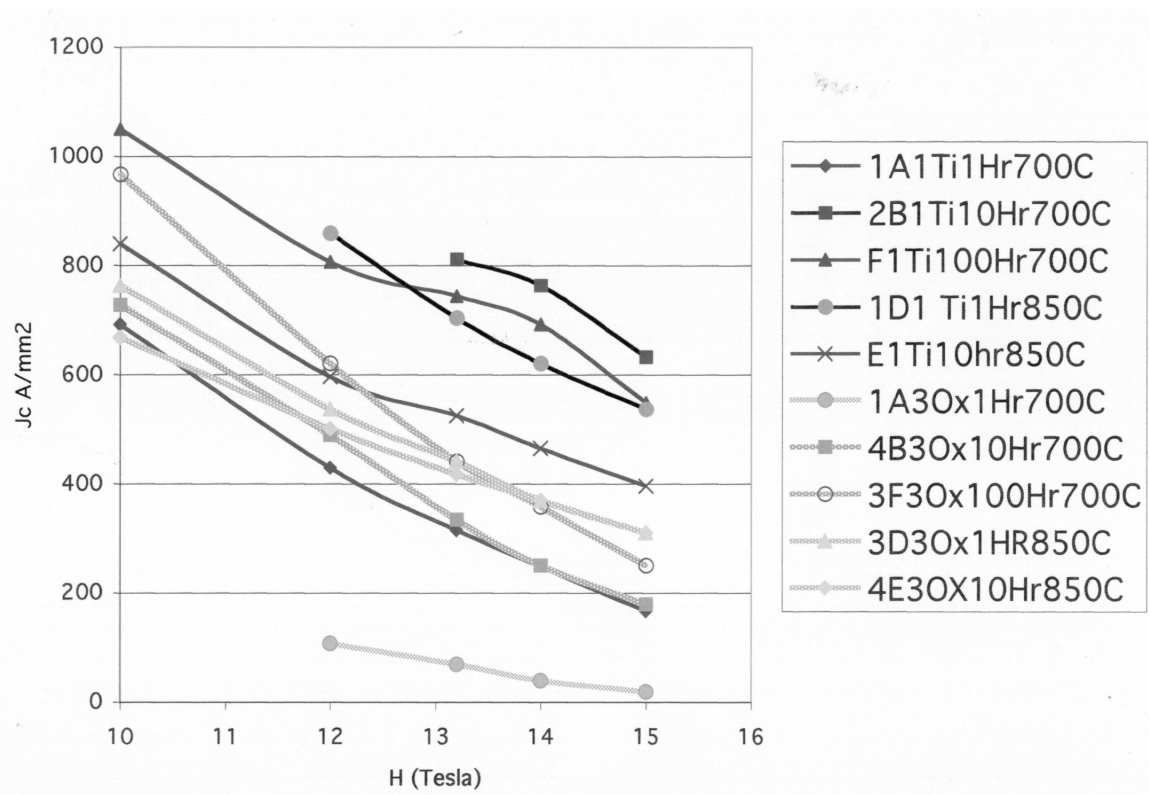


Figure 18. J_c vs. H for Sn+Ti and Sn+SnO at various heat treatments.

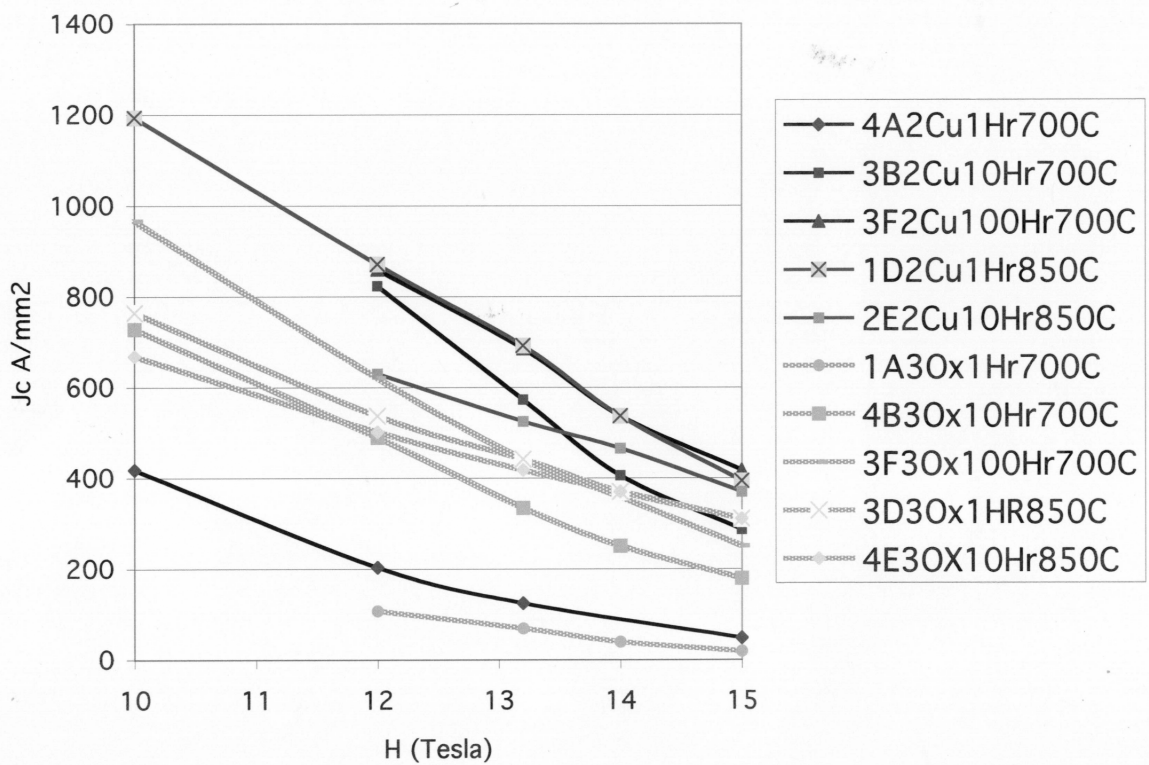


Figure 19. J_c vs H for Sn+Cu and Sn+SnO for various heat treatments.

TABLE VI
ZAB4 % Reaction, Grain Size and Heat Treatment Condition

Sample	Reaction %+/- 8%	Grain Size nm	Grain Size s.d
A1 Sn+Ti 700°C 1 hr	45	74	29
A2 Sn+Cu 700°C 1 hr	37	69	31
A3 Sn+O 700°C 1 hr	23	71	23
B1 Sn+Ti 700°C 10 hr	87	85	29
B2 Sn+Cu 700°C 10 hr	91	102	28
B3 Sn+O 700°C 10 hr	57	89	23
F1 Sn+Ti 700°C 100	100	184	68
F2 Sn+Cu 700°C 100	100	155	57
F3 Sn+O 700°C 100	84	188	71
D1 Sn+Ti 850°C 1 hr	100	298	134
D2 Sn+Cu 850°C 1 hr	100	210	110
D3 Sn+O 850°C 1 hr	93	412	163
E1 Sn+Ti 850°C 10 hr	100	463	218
E2 Sn+Cu 850°C 10	100	392	175
E3 Sn+O 850°C 10 hr	93	406	177
G1 Sn+Ti 1000°C 1hr	100	1651	715
G2 Sn+Cu 1000°C 1	100	943	427
G3 Sn+O 1000°C 1 hr	100	719	259

Figure 20 presents the layer current density as a function of time and reaction temperature. It is the clearest illustration of the effects of the additions. The layer current density of the Cu+Sn and the Cu+Sn+SnO₂ are similar at 700°C with the slightly higher value of the Cu+Sn possibly due to the higher Sn content. The Ti sample is clearly superior though at 850°C the values converge with the increase in time. The O+Sn sample appears it will be superior for times greater than 10 hours at 850°C.

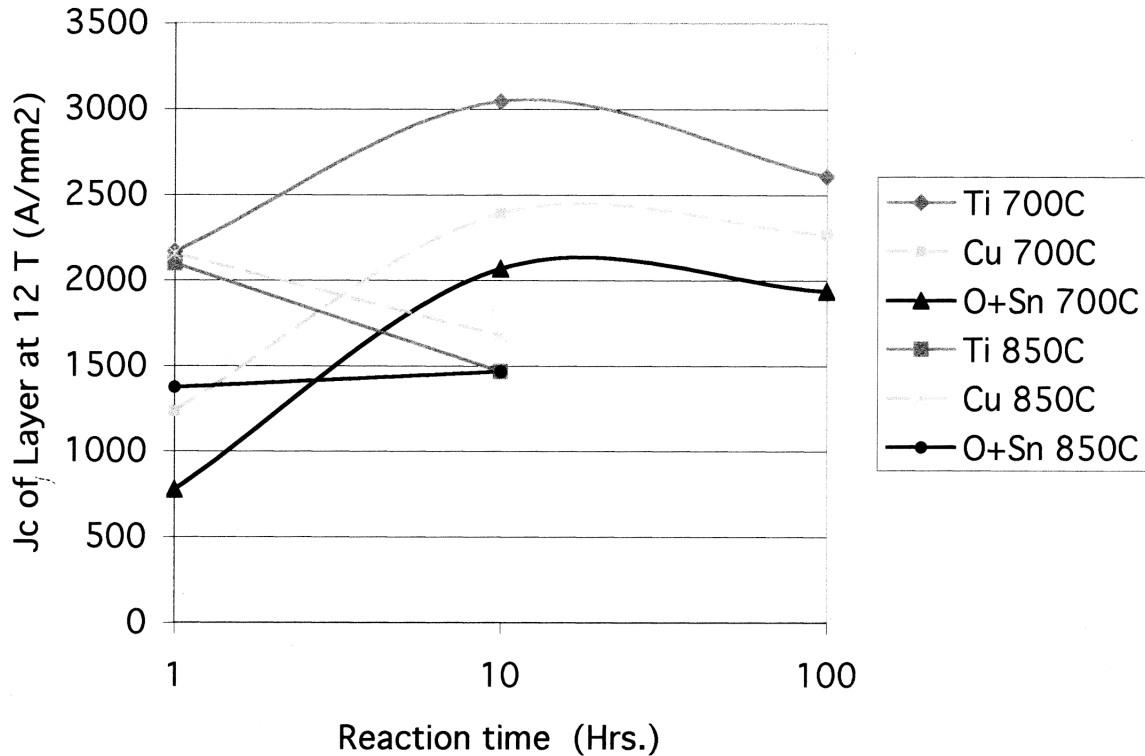


Figure 20. Layer Jc at 12 T vs. reaction time for ZAB4 with Ti, Cu, SnO₂ additions.

Measurements of the 1000°C samples showed a marked drop in apparent H^* with the SnO₂ sample having an H^* of 10 T. The other samples appeared to be resistive above 6 T. Kuranhashi, et al reported a marked drop in T_c and B_{c2} in bronze matrix conductors between a peak of 850°C and 940°C with B_{c2} at 940°C of 20T[48]. Also the ternary appears to show 2 at% of Cu in solution though there is some disagreement in phase diagrams.

Recently work by Dr. L. Cooley (unpublished) has raised concerns about the formation of ZrO₂ because the great solubility of Oxygen in Nb. Work done by L.E. Rumaner indicates that the ZrO₂ only forms in the Nb₃Sn and in fact requires the solubility of O in Nb for the mechanism to work [49].

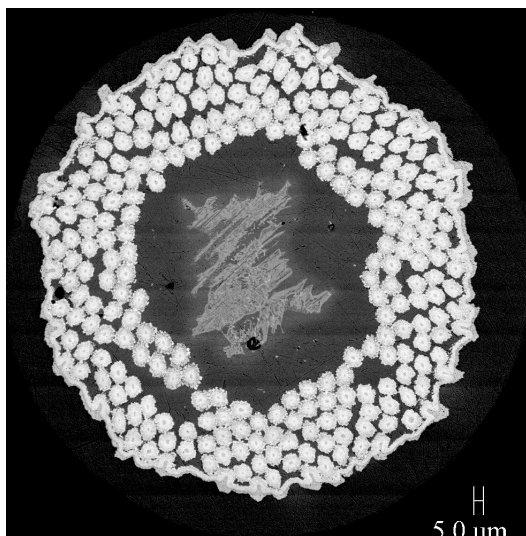
Heat treatments in the above work covered the range from 700°C to 1000°C. The oxygen sample at 1000°C for one hour showed smaller grain size but depressed H^* . Investigating more closely the 850°C to 900°C temperature range appeared called for. Samples were heat treated straight in flowing high purity Ar atmosphere within alumina tubes wrapped with Ta foil. The samples were ramped at 6°C/hr to 210°C and held for 32 hrs., ramped at 10°C/hr. to 400°C, held for 24 hrs., ramped to 575°C at 50°C/hr., held for 1 hr., and then ramped at 300°C/hr. to the final temperature. Table VII gives the final heat treatment times and temperatures in addition to the grain size, and area reaction.

Table VII
Heat Treatment Results with Respect to Grain Size and Area Reaction for ZAB4

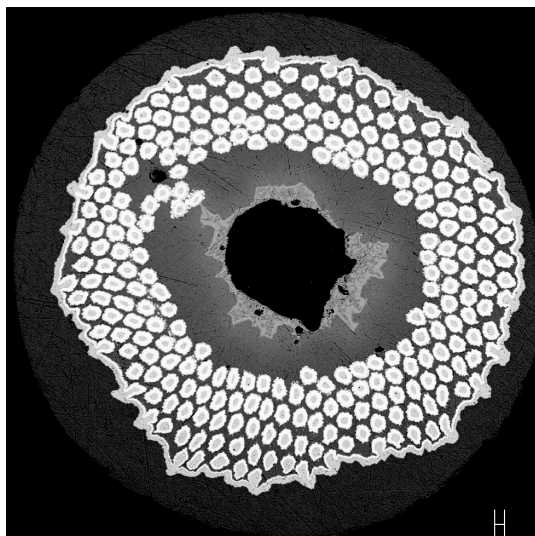
Sample and HT Temperature °C	Time (min)	Reaction Area Microns ²	% Reacted	Mean Grain Size (nm) and S.D.
#15 Sn+Ti -850	6	61.2	97.7	429 +/-19
#17 Sn+Ti -850	30	62.6	100	550 +/-18
#5 Sn+Ti - 850	60	62.6	100	454 +/- 19
#16 Sn+SnO ₂ -850	6	40	65	273 +/-43
#18 Sn+SnO ₂ -850	30	49	79	404 +/-40
#6 Sn+SnO ₂ -850	60	50	81	368 +/-68
#4 Sn+Ti-900	6	62.6	100	415 +/-19
#9 Sn+Ti-900	30	62.6	100	477 +/-19
#13 Sn+Ti-900	60	62.6	100	439 +/-19
#3 Sn+SnO ₂ -900	6	45	73	368 +/-68
#10 Sn+SnO ₂ -900	30	50	81	434 +/-53
#14 Sn+SnO ₂ -900	60	55	89	327 +/-26

The heat treated samples of ZAB4 with SnO₂ additions and Sn+Ti were analyzed with respect to reaction area, percent reaction and grain size. Table VII presents the results of the measurements. Figure 21a. and b. compares the as reacted cross sections at 6 minutes for 850°C between the Ti and SnO₂ samples. Figure 22a. and b. compares the effect at 900°C for 60 minutes.

Current vs. magnetic field measurements were made at Lawrence Berkeley National Laboratory 15 T superconducting magnet. The samples were straight and mounted perpendicular to the field on a four sample holder. The samples were about 31 mm long with 9.5 mm current contact pads and potential leads about 5 mm apart. One microvolt defined the current. The best of two values was used as the 0.25 mm wire was easy to damage. Figure 24a, and b. give the layer current density of the 850°C and 900°C measurements of ZAB4.

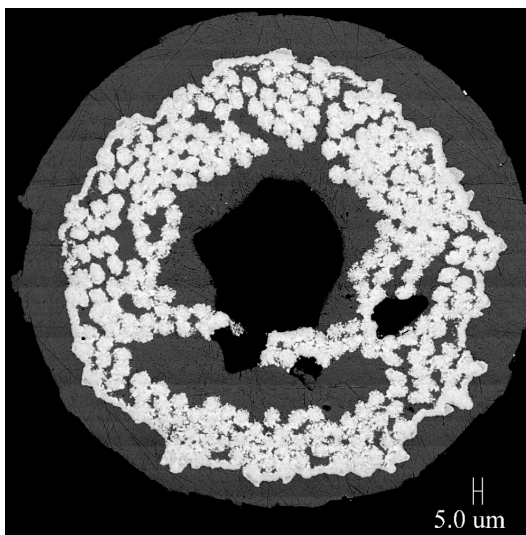


a.

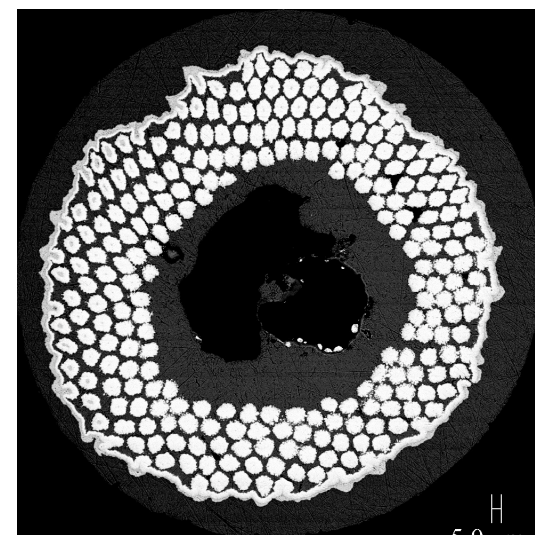


b.

Figure 21a. ZAB4 #15 Sn+Ti 6 min at 850°C b. ZAB4#16 Sn+SnO₂ 6 min. at 850°C



a.



b.

Figure 22a. ZAB4#13 Sn+Ti 60 min at 900°C b. ZAB4#14 Sn+SnO₂ 60 min at 900°C

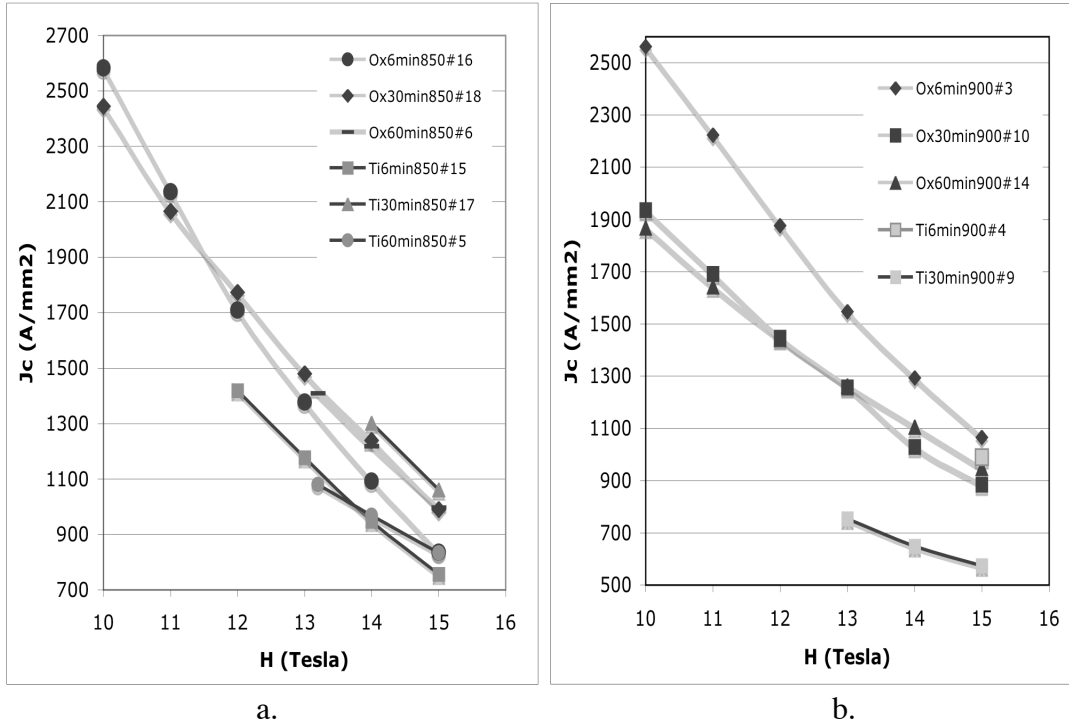


Fig. 24a. Layer current density vs. H for 850°C b. Layer current density vs. H for 900°C.

The cross sections in figure 21a with the Ti addition shows 97% reacted filaments that have partially dissolved and moved significantly. In contrast figure 21b with oxygen addition shows a much more uniform 65% reacted filament and array. Previous work indicated that the addition of oxygen slowed the reaction by about a factor of 10. Figure 22a shows a broken barrier with extreme movement of filaments suggesting local liquid phases while in figure 22b, the sample with the oxygen filaments are 89% reacted with an intact barrier.

The average grain size measurements seem to indicate that the 60 minutes gives smaller grains than the 30 minutes. The variation in the local tin concentration and environment as well as the accuracy of the measurement probably explains this. The average grain size of the two Ti samples (#9, #13) at 900°C is 458 \pm 19 while the two oxygen samples (#10, #14) is 380 \pm 39.5. There is not a dramatic effect on the grain size of the Nb₃Sn due to the presence of the SnO₂.

Figure 24a. illustrates the layer current for the reaction at 850°C. At 12 T the Ti extrapolated value would be the best. Previous work at 700°C yielded a nominal 3045 A/mm² in the Ti samples vs. a nominal 2068 A/mm² for the oxygen samples. In figure 24b the oxygen bearing samples J_c has increased over the Ti samples for all fields. The 15T 900°C value of the oxygen sample (1065 A/mm²) is superior to its 850°C value (998 A/mm²) though further optimization could change the result. Note, the layer J_c for 700°C heat treatments of these conductors is comparable to ITER type conductors which are similar in Nb and Sn composition.

The GE tape process conductors fully optimized to reaction time, temperature and full oxidation of the Zr to ZrO_2 had an average grain size of 250-300 nm. The current density of the GE tape extrapolated from 5 T data scaled from their J_c vs. H curve measured to 20 T yielded at 12T, 2700 A/mm² and 1300 A/mm² at 15T. By the GE model a grain size of 380 nm would yield current density of 1450 A/mm² at 12 T vs. our measured 1900 A/mm². This implies that with further work on optimization that J_c values might be improved. Still, the extrapolated values to 12 T of GE's tape layer current density, 2700 A/mm² are significantly below 4300 to 4500 A/mm², currently achieved in the best internal tin conductors. The GE tape though does not use third element additions such as Ti and or Ta to improve the properties. The addition of Ti to the Nb1Zr in addition to oxygen remains to be explored in the MEIT conductor.

The apparent effect of oxygen using the SnO_2 method is to slow the reaction, and stabilize the filaments and matrix at high reaction temperatures. If, continuous high speed reaction is required in a multifilament process then the addition of oxygen by this method would make this feasible.

Reconsideration of the original GE process suggested that since the tape process reaction was in liquid phase that we should look to lower the temperature of reaction to just stay within the liquid phase region. This would reduce the grain size as well as better duplicating the reaction situation in which the ZrO_2 restricted grain growth. The boundary in the tin content of our materials is at 798°C in the phase diagram.

A series of heat treatments were carried out on ZAB4 at 785 and 815°C, straddling the phase boundary at Supramagnetics in their new box furnace. All samples had a pretreatment of 24 hr. at 210°C, ramped to 400°C at 10°C/hr. held for 24 hrs. ramped to 575°C at 50°C/hr. held for 1 hr. and then heat treated at 785°C and 815°C for 1, 3 and 10 hrs. Grain size was measured on each sample though only one filament of each was used. Figure 25 shows an un-reacted sample of ZAB4 at 0.254 mm dia. prior to reaction. The tin core is off center due to drill wander. This could lead to local melting in the reaction process.

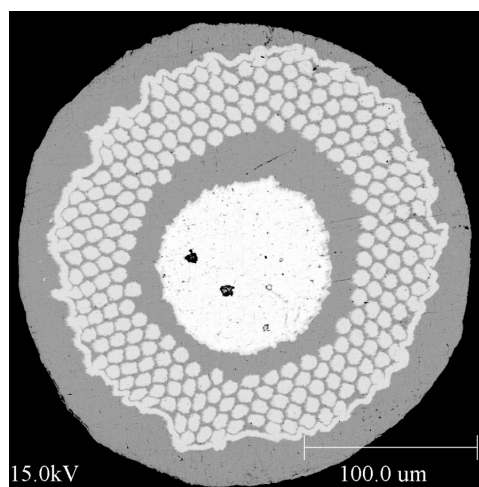


Fig. 25. ZAB4-1 Oxygen 0.254 mm

Figure 26 a. and b. show the reacted cross sections of ZAB4 with for 3 hrs at 785 and 815°C. These show the extremes of the images. The 10 hrs samples show 100% reaction for both temperatures. The 815°C 1 hr. sample shows about 90% reaction.

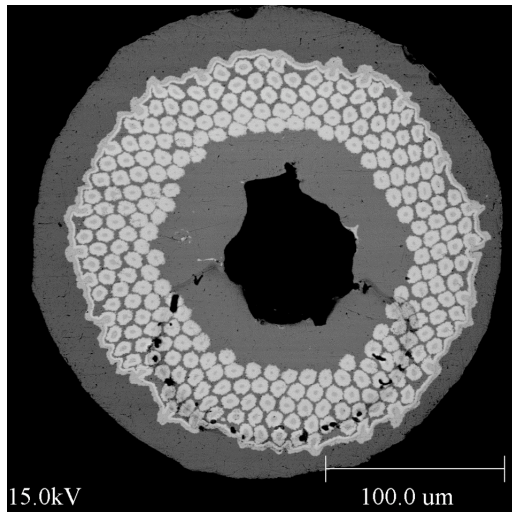
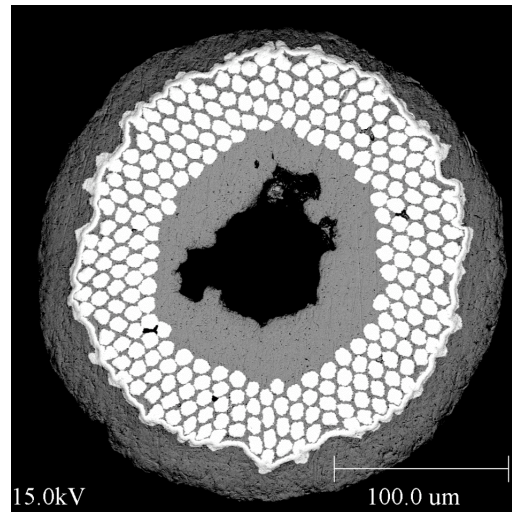


Fig.26a. ZAB4 Oxygen 3 hrs. 785°C



b. ZAB4 Ox 3hrs.815°C

Fig. 27a shows the reacted cross section of the Ti addition to ZAB4. Both are essentially 100% reacted. This again illustrates the enhanced reaction kinetics from Ti addition. At 1 hour for both temperatures reaction is almost complete. Fig. 28a. and b. show ZAB4 without any additions. The 785°C shows signs of melting in the reaction sufficient to move the filaments though the 815°C does not. Reaction in both are 100%. All the 785°C samples show distorted arrays due to local melting. The 815°C do not. The 1 hr sample at 785°C showed quite a number of partly un-reacted filaments while the sample at 815°C showed fully reacted filaments. Thus the possibility of sample mix up seems not to be the explanation.

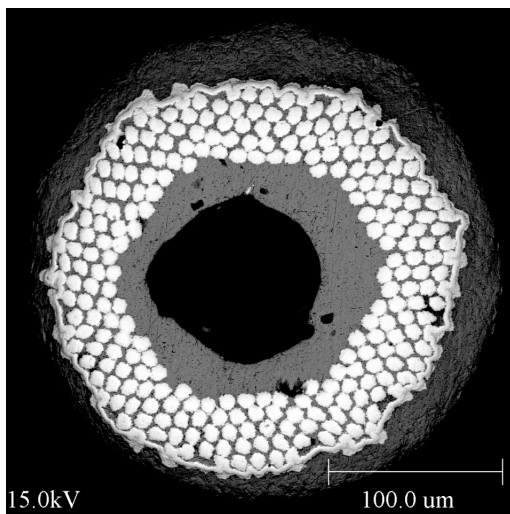
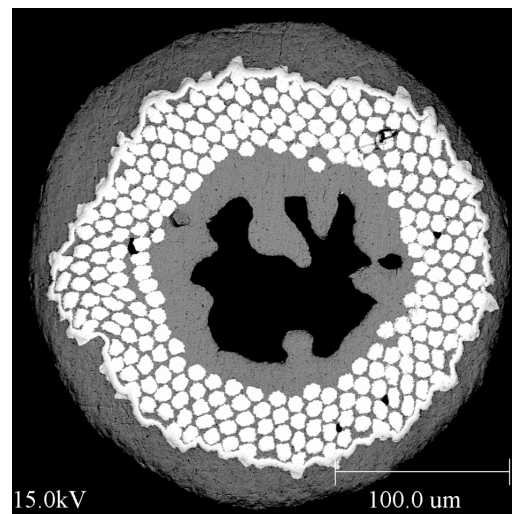


Fig. 27a. ZAB4+Ti 3 hrs. 785°C



b. ZAB4+Ti 3 hrs. 815°C

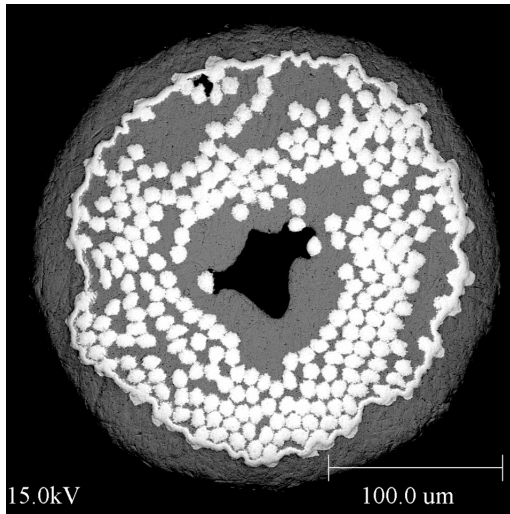
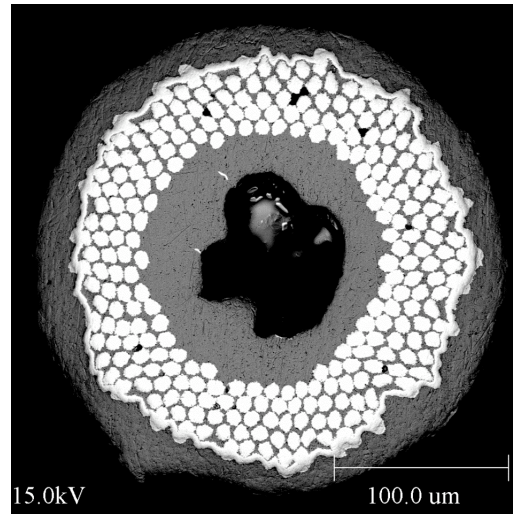


Fig. 28a. ZAB4 3 hrs. 785°C



b. ZAB4 3 hrs. 815°C

Additional cross sections of the samples at 785°C showed that 10 out of 12 non doped (Cu) samples had distorted arrays similar to Fig. 28a. while 2 out of 12 of the Ti samples also showed distorted arrays. No distorted arrays were found in any of the 815°C heat treatments nor were any found in the Oxygen samples.

Grain size measurements were made at GECR&D using the linear intercept method. Figure 29 plots the results for the 3 and 10 hr. heat treatments for the samples. A typical filament was measured in each. Grain size appeared similar within a sample. The 10 hr. trend confirms that Oxygen is effective in controlling the grain size as is Ti. Grain sizes fit within the boundaries previously measured such as in Table VI.

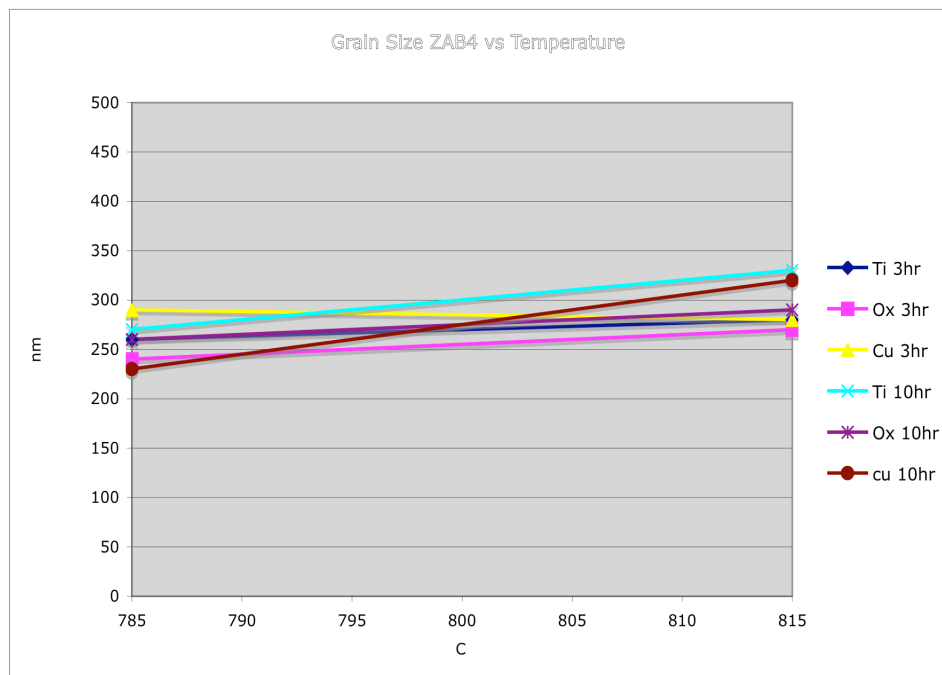


Fig. 29. Grain size vs. reaction temperature of various ZAB4,+Cu,+Ox,+Ti

Table VIII

Type	Temp °C	Time Hrs	area reacted	% reaction	Grain Size	observation
SnOx1hr785	785	1	42.3	75.0%	200	
SnOx1hr785	785	1	56.3	90%	200	
SnOx3hr785	785	3	62.6	100%	240	
SnOx10hr785	785	10	62.6	100%	260	
SnOx1hr815	815	1	61.4	98%	270	
SnOx3hr815	815	3	62.6	100%	270	
SnOx10hr815	815	10	62.6	100%	290	
CuSn1hr785	785	1	56.3	90%	260	distorted array
CuSn3hr785	785	3	62.6	100%	290	distorted array
CuSn10hr785	785	10	62.6	100%	230	distorted array
CuSn1hr815	815	1	62.6	100%	250	distorted array
CuSn3hr815	815	3	62.6	100%	290	distorted array
CuSn10hr815	815	10	62.6	100%	320	distorted array
SnOxR10hr815	815	10	62.6	100%	290	
CuSnR1hr815	815	1	62.6	100%	250	distorted array
CuSnR3hr815	815	3	62.6	100%	290	distorted array

Table IX

H (Tesla)	<u>12</u>	<u>13</u>	<u>14</u>	<u>15</u>
n values				
SnOx1hr785	29	29	28	
SnOx1hr785	33	32	25	
SnOx3hr785	15	14	14	
SnOx10hr785	72	44	50	
SnOx1hr815	20	29	33	44
SnOx3hr815	52	25	97	17
SnOx10hr815			17	9
CuSn1hr785	17	16	11	8
CuSn3hr785	27	24	22	15
CuSn10hr785	17	10	24	11
CuSn1hr815	29	23	16	32
CuSn3hr815			30	27
CuSn10hr815				
SnOxR10hr815	62	35	21	11
CuSnR1hr815		37	10	28
CuSnR3hr815	43	39	22	

Table VIII lists the area of reaction, % reaction, grain size and comments of the array of the samples tested. Table IX lists the “n” values for the samples tested by Dr. Arno Goedeke and Dr Dan Dietderich of LBNL using the same probe and magnet as in previous tests.

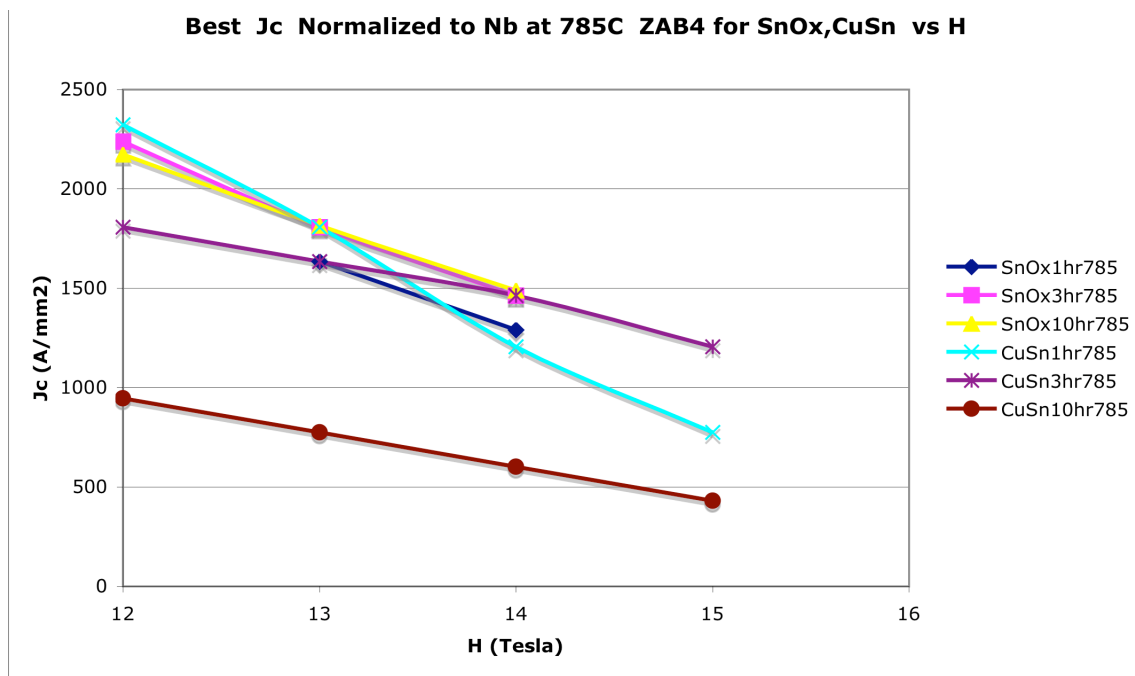
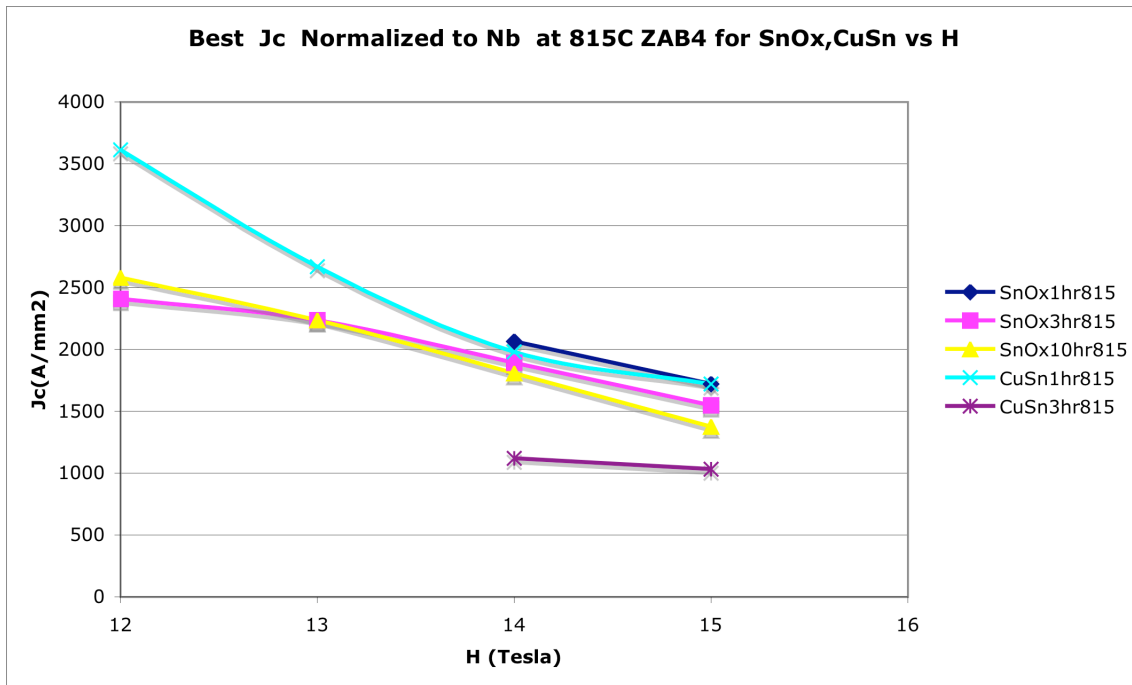


Figure 30

Some samples exhibited flux jumping, and or motion effects that resulted in quenching at lower fields. The best results for current density normalized to the Nb at 775°C, and 815°C are graphed in figure 30 and 31. The best layer current density as a function of temperature for all samples is summarized in figure 32.

Figure 31



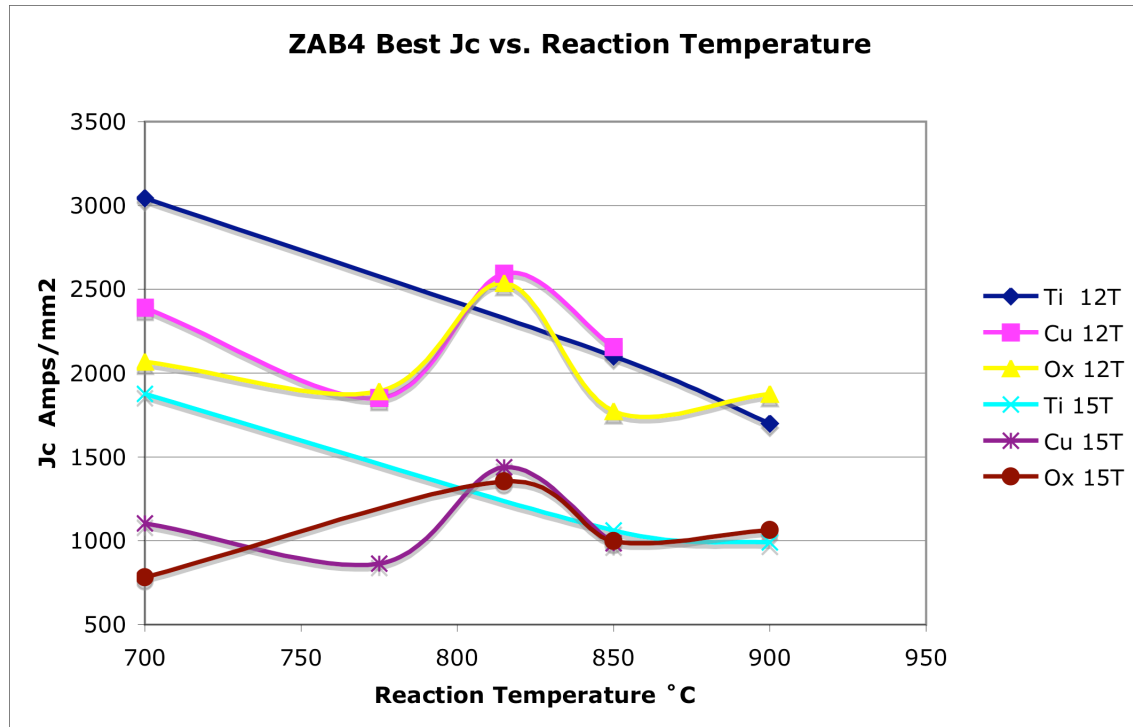


Figure 32

Both the SnOx sample and CuSn samples have a peak at the 825°C reaction temperature for both 12 and 15T. 15T results are felt to best represent the maximum values as at those currents and fields the samples were stable. Ti samples were not measured due to insufficient funds. The grain size of the samples are similar at 1hr 815°C as seen in table VIII (270,250 nm). These grain sizes are substantially below the 1 hour at 850°C, 368+/-68 nm. Even though the Cu samples have no intentional Oxygen added there is probably detectable amounts sufficient to form some ZrO₂. Since we don't know how much is actually needed to have an effect we can only conjecture that it might have been enough. Further work is needed with (Nb1Zr)₃Sn with higher tin and more filaments to see if this enhancement in layer J_c will be additive to the effect associated with higher tin contents.

Attempts to incorporate TiO₂ with the Sn core yielded a low density core which we were unable to process. Other methods could not be explored due to insufficient funds.

8.3 The effect of Zr & O₂ on properties in rod-in-tube billet materials

Work on this was based on being able to add oxygen to the copper matrix. That has proven unfeasible as well as unnecessary now that we have other techniques. Efforts intended in this area were shifted to 8.1 which had proven more difficult than planned.

8.4 Use of clad rods in two conditions to improve non-Cu Jc

Two five inch (127 mm) diameter billets were designed (.71/1 & .57/1). These designs use copper clad Nb1Zr rods to increase the local Nb1Zr ratio. The resulting conductor

are more representative of present HEP conductors which have high Nb percentages as well as high Sn percentages while minimizing copper. Hopefully the high LAR will process with less sausaging than in low LAR conductor ZAB4. Materials were ordered and delivered

The Nb1Zr rods were clad with copper at Outokumpu A.S. for the two ratios and drawn to 0.129" across the flats hexes. Work was stopped after the testing results at LBL were analyzed. There were insufficient funds to complete this task.

8.5 Repeat of work with Nb1Zr cast with 2 at% Oxygen

Several hundred rods of 2.348 mm diameter Nb1Zr rods were heat treated with Nb_2O_5 powder in vacuum at 1100 C for 100 hours to add oxygen. Analysis indicated 0.415 wt% was absorbed by the rods. Section 8.1 in this covers this in more detail. Two 51 mm billets, ZAB5 & 6, were assembled with these rods and a Nb diffusion barrier. Three pure Nb marker filaments were included to compare filament reaction within the matrix. ZAB5 had 89 filaments while ZAB6 had 90. The billets were hipped and extruded to 12.192 mm with ZAB5 extruded at 450°C and ZAB6 at 500°C. As can be seen in figure 25 there is some non-uniformity of the filaments though not as severe as some of the original extrusions in Phase I.

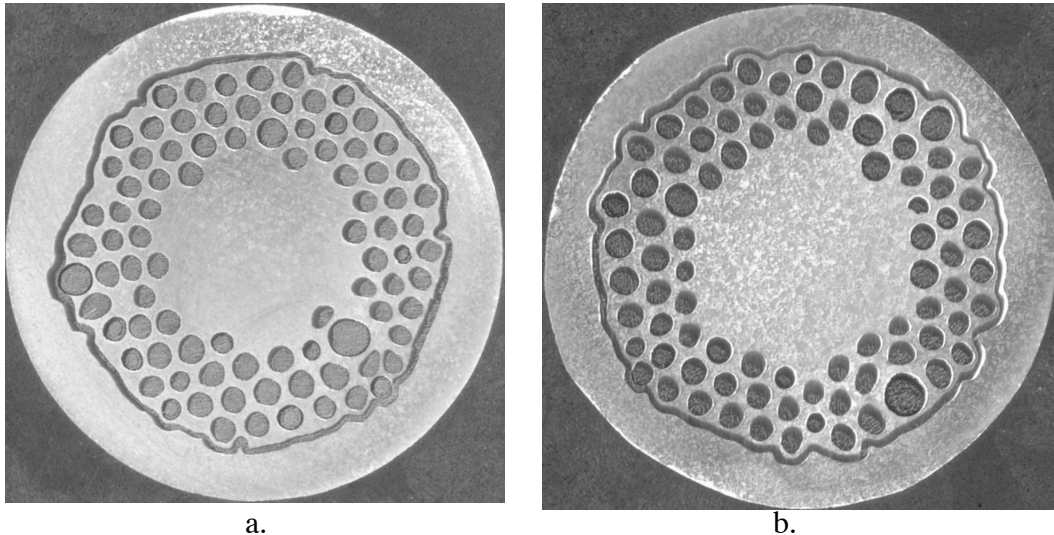


Figure 25a. ZAB5 12.19 mm dia. extruded at 450 °C and (b) ZAB6 extruded at 500°C

Micro-hardness measurements were made on the as extruded rod. The large filaments had a VHN of 420 while the regular filaments had a VHN of 130. This large variation in hardness may indicate that the oxygen absorption was far from uniform. It is possible that some rods were touched by the powder. As discussed in the first section hardness of the starting material was not uniform across the radius. Figure 26 shows the sausaged filaments after extrusion once the copper has been removed.

The rod was gun drilled by Grover with a 0.147" I.D. Then drawn with a high reduction schedule of 0.410", 0.348", 0.295" and finally with a standard 20% die schedule. Breakage began at 0.224" mm with the second break at 0.157" mm and a final break at 0.122" mm where drawing was stopped. Figure 27 shows the wire at 0.122" with highly variable filament sizes.

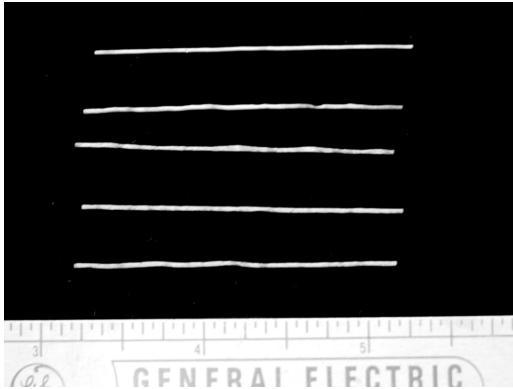


Figure 26. ZAB5 filaments after extrusion

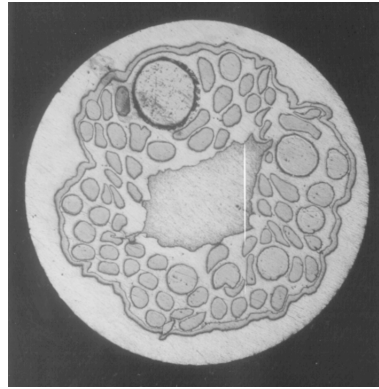


Figure 27. ZAB5 at 0.122" dia.

The Nb1Zr rods used as used in the prior billets were further heat treated at 1600°C for one hour to diffuse the oxygen in further. Figure 28 shows that the oxygen has diffused in to give a more uniform and lower hardness. Figure 29 shows the rod's hardness profile as in ZAB5,6. A 50 mm billet was assembled with 0.097" rods and extruded using the same parameters as in ZAB5 and ZAB6. The extruded section is shown in figures 30 a. and b. Several filaments are irregular but do not appear to be harder than the other filaments.

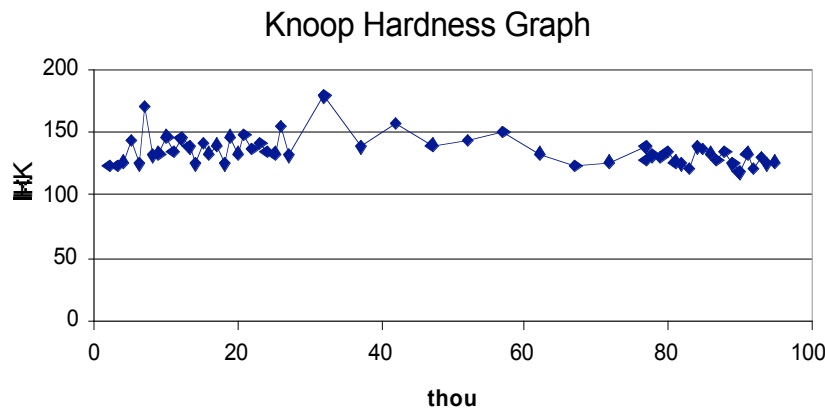


Figure 28. Knoop Hardness vs. distance in thousandths of an inch from edge of rod annealed at 1600°C for 1 hr.

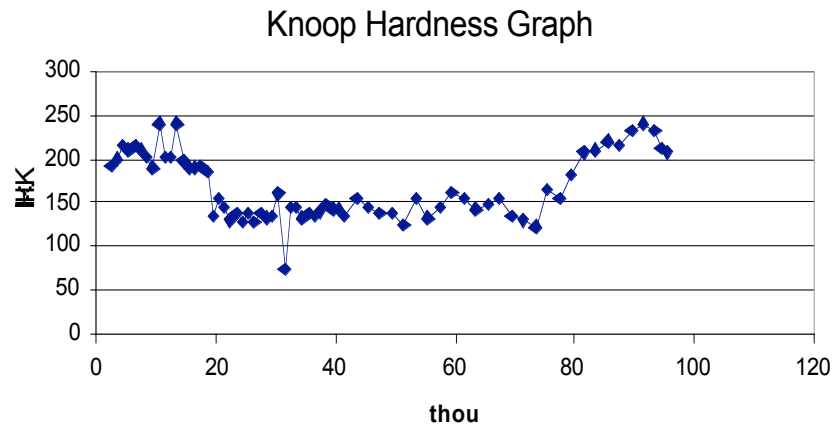
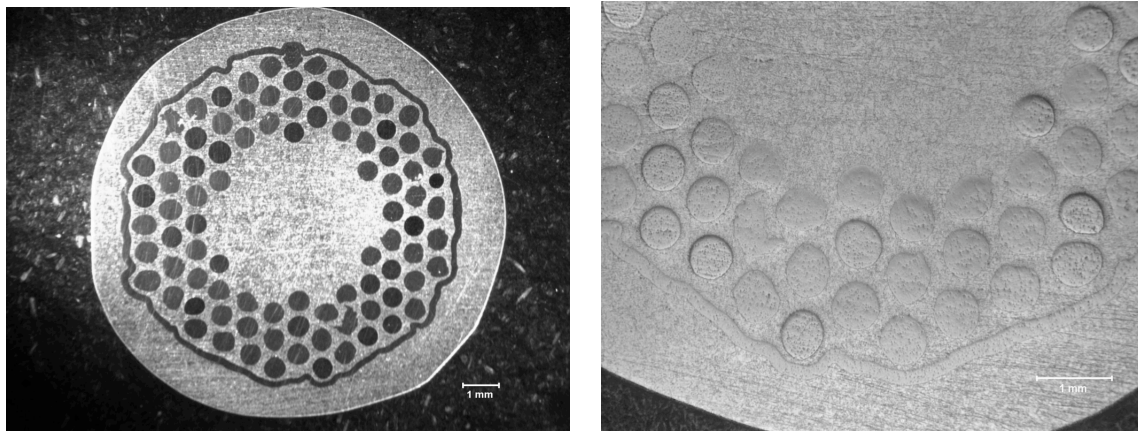


Figure 29. Knoop Hardness of same rod after 1100°C for 1 hr.



a.

Figure 30a. ZAB8 at 12.7 mm diameter

b.

b. ZAB8 filament barrier area

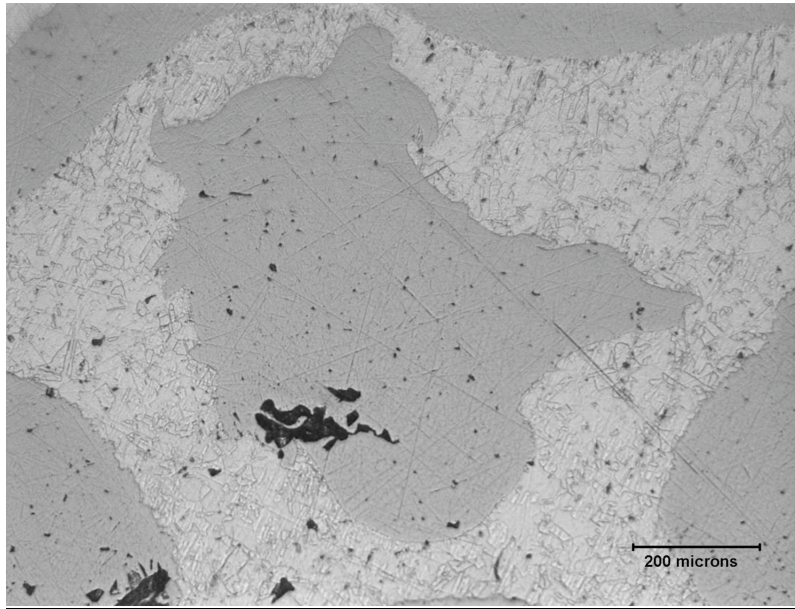
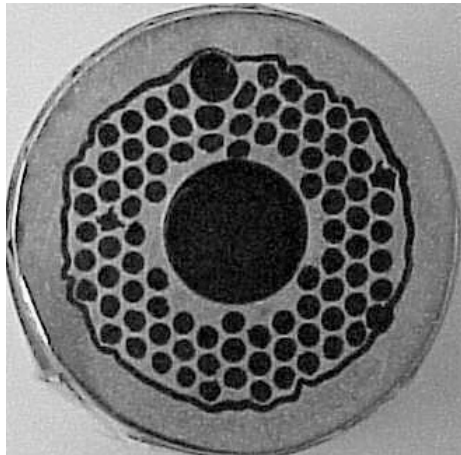


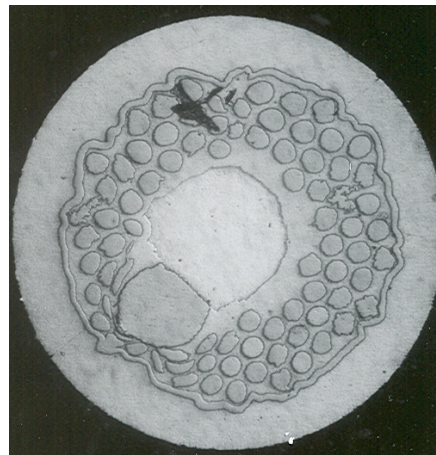
Figure 31. ZAB8 irregular filament

Oxygen analysis on the rods used in ZAB8 indicated that 0.41 wt% was absorbed more than sufficient to react with the Zr. The resulting rod was gun drilled with a 3.73 mm hole, tin inserted and drawn to 10.41 mm, 8.83 mm, 7.49 mm, and then using a standard 20% area reduction die schedule. Breaks began at 2.59 mm and continued to 1.62 mm where drawing was stopped. Further cross sections were taken at the as extruded size which indicated some large filaments. Figure 32 shows the as extruded rod and the wire at 1.62 mm.



a.

Figure 32a. As extruded ZAB8



b.

b. As drawn to 1.62 mm

Hardness measurements were made on ZAB8 extruded filaments. The large filaments were 366 VH (20 gram load). The regular filaments were 177 VH while the deformed filaments were 150VH. The Nb barrier was 167 VH.

Samples of the wire at 1.62 mm were sent to SupraMagnetics Inc. for grooved rolling. They were able to reduce the material to 0.91 mm and to a 0.22 mm tape. This was encouraging as it demonstrated that the material on average was sufficiently ductile. These samples after heat treatment showed extreme tin leaks as the rolling process broke the barriers. They were unsuitable for further analysis.

Conclusion

The addition of Oxygen to Nb1Zr multifilament conductors has been shown to allow higher reaction temperatures from 815°C to 1000°C. The oxygen addition appears to stabilize the filament matrix in comparison to the nondoped samples. A continuous reaction of the conductor would be feasible if so required. The J_c enhancement effects were only seen at 815°C, though the effect was substantial (approximately 50% at 15T). This appeared in both the Sn+Ox, and Cu+Sn samples. The Ti sample was not tested. Further work on higher Sn composites would be warranted to see if the effects on layer J_c would be additive.

Techniques were developed to incorporate and process Nb1Zr with controlled amounts of Oxygen. Unfortunately local variations on some rods led to difficulties in processing.

Finally, work to combine the known benefits of Ti additions with Oxygen in Nb1Zr might yield substantial improvements.

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